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(54) **POLARIZATION ROTATING PHASED ARRAY ELEMENT**

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H01Q 21/22 (2006.01)
H01Q 15/14 (2006.01)
(Continued)

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CPC **H01Q 21/22** (2013.01); **H01Q 3/36** (2013.01); **H01Q 15/14** (2013.01); **H01Q 21/0006** (2013.01)

(58) **Field of Classification Search**
CPC H01Q 21/22; H01Q 21/0006; H01Q 21/0025; H01Q 25/00; H01Q 3/26;
(Continued)

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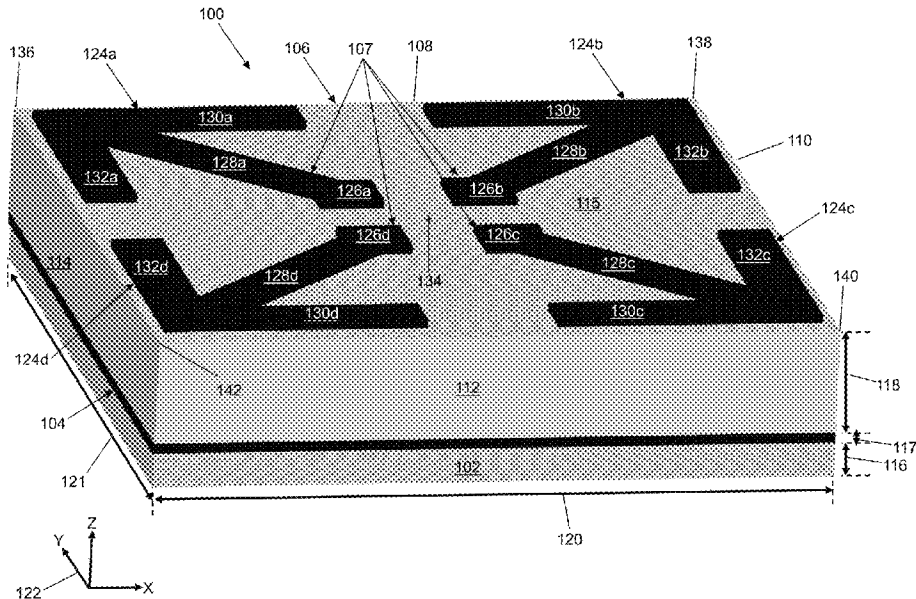
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(57) **ABSTRACT**

A phase shifter includes a first dielectric layer, a switch mounted to the first dielectric layer, a conductive layer mounted to the first dielectric layer, a second dielectric layer mounted to the conductive layer, a conducting pattern layer mounted to the second dielectric layer, and a plurality of vias. The switch is switchable between a first conducting position and a second conducting position. Each via is connected between a first or a second throw arm of the switch and a conductor of the conducting pattern layer. When an electromagnetic wave incident on the phase shifter is reflected, an electric polarization of the reflected electromagnetic wave is rotated by ± 90 degrees compared to an electric polarization of the incident electromagnetic wave based on a conducting position of the switch. The phase shifter can be used as one-bit spatial phase shifter to provide either 0° or 180° phase shift over wide bandwidths.

20 Claims, 31 Drawing Sheets



- (51) **Int. Cl.**
H01Q 21/00 (2006.01)
H01Q 3/36 (2006.01)
- (58) **Field of Classification Search**
 CPC H01Q 3/36; H01Q 3/267; H01Q 3/267G;
 H01Q 15/14
 USPC 342/368
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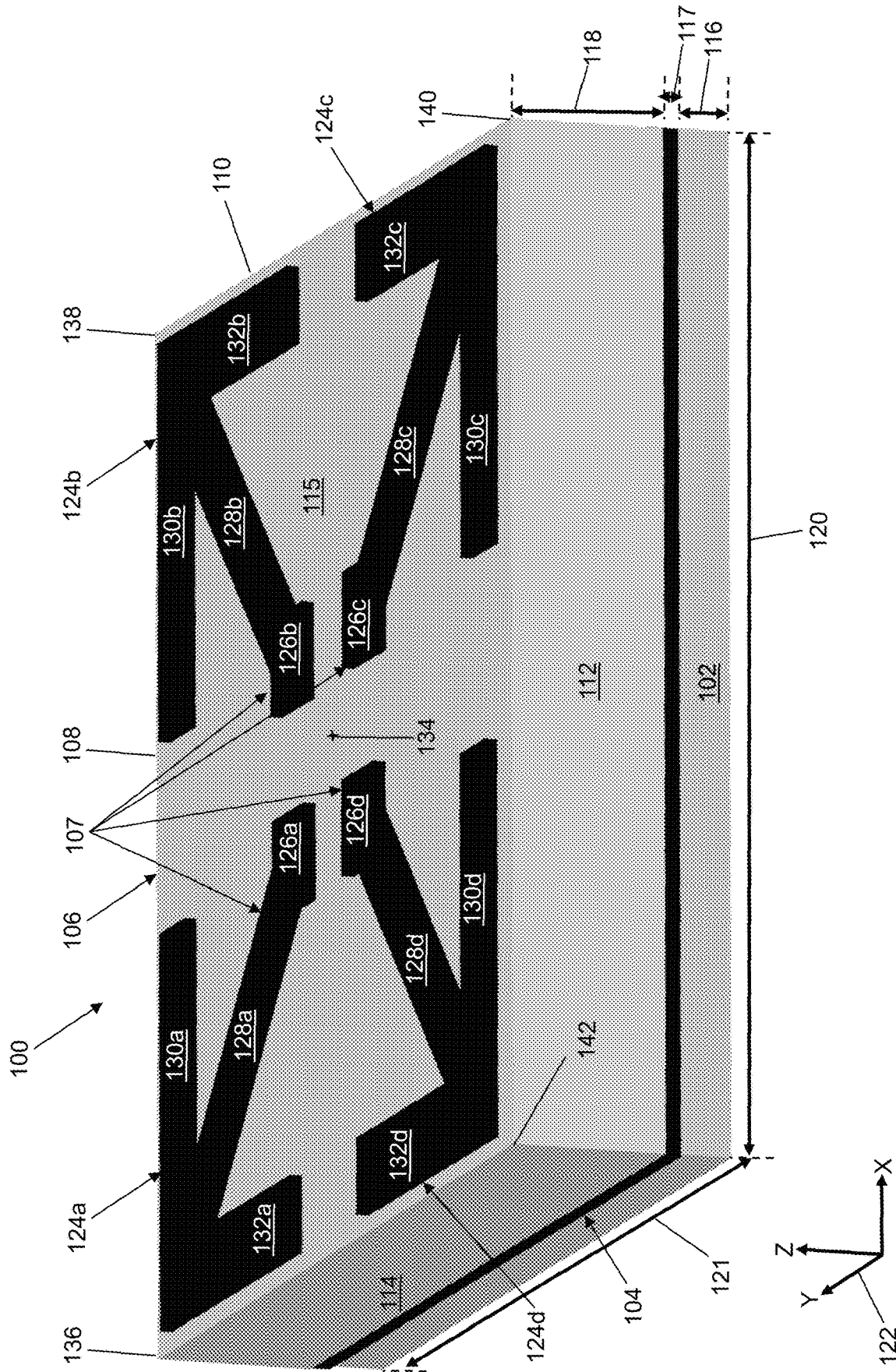
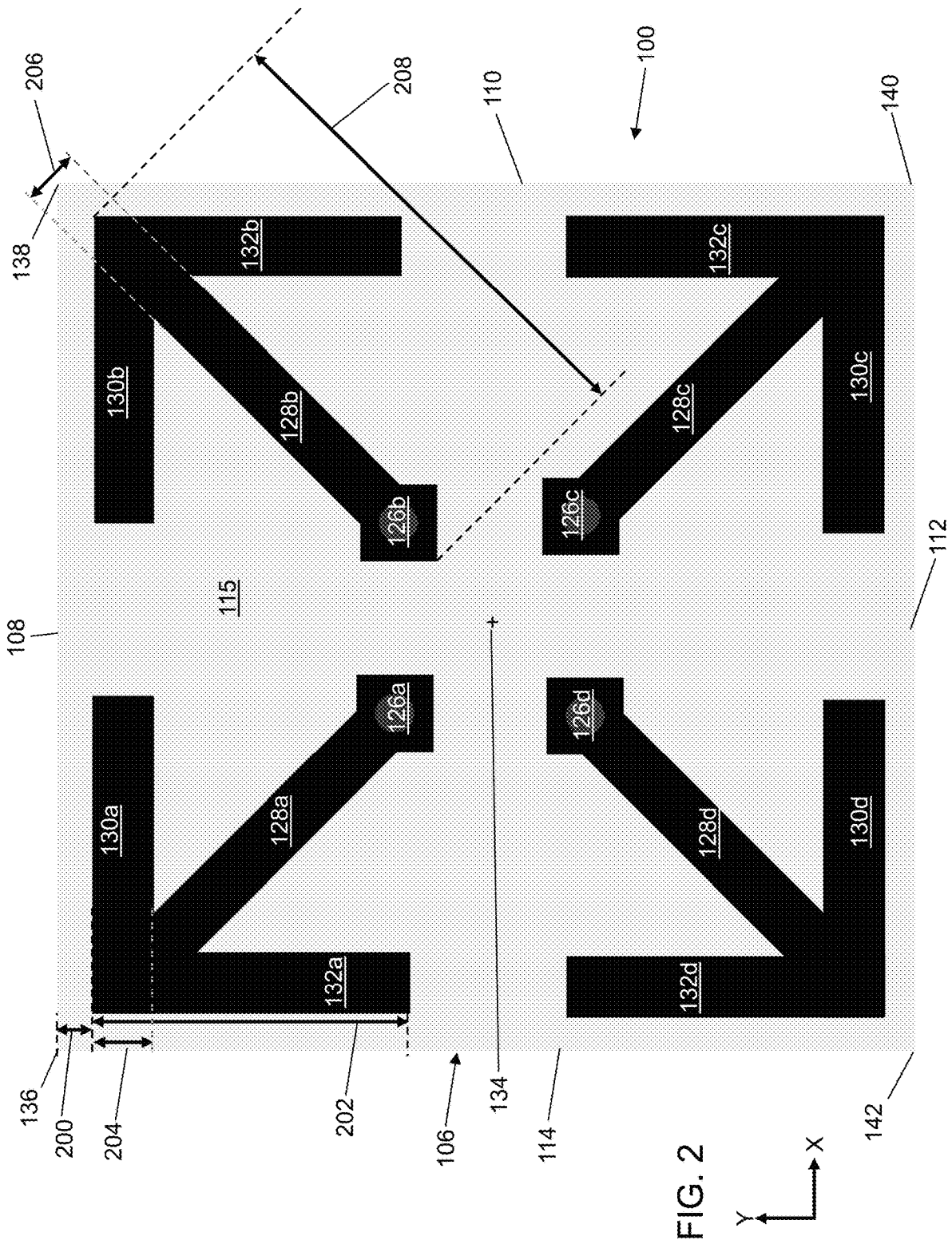


FIG. 1



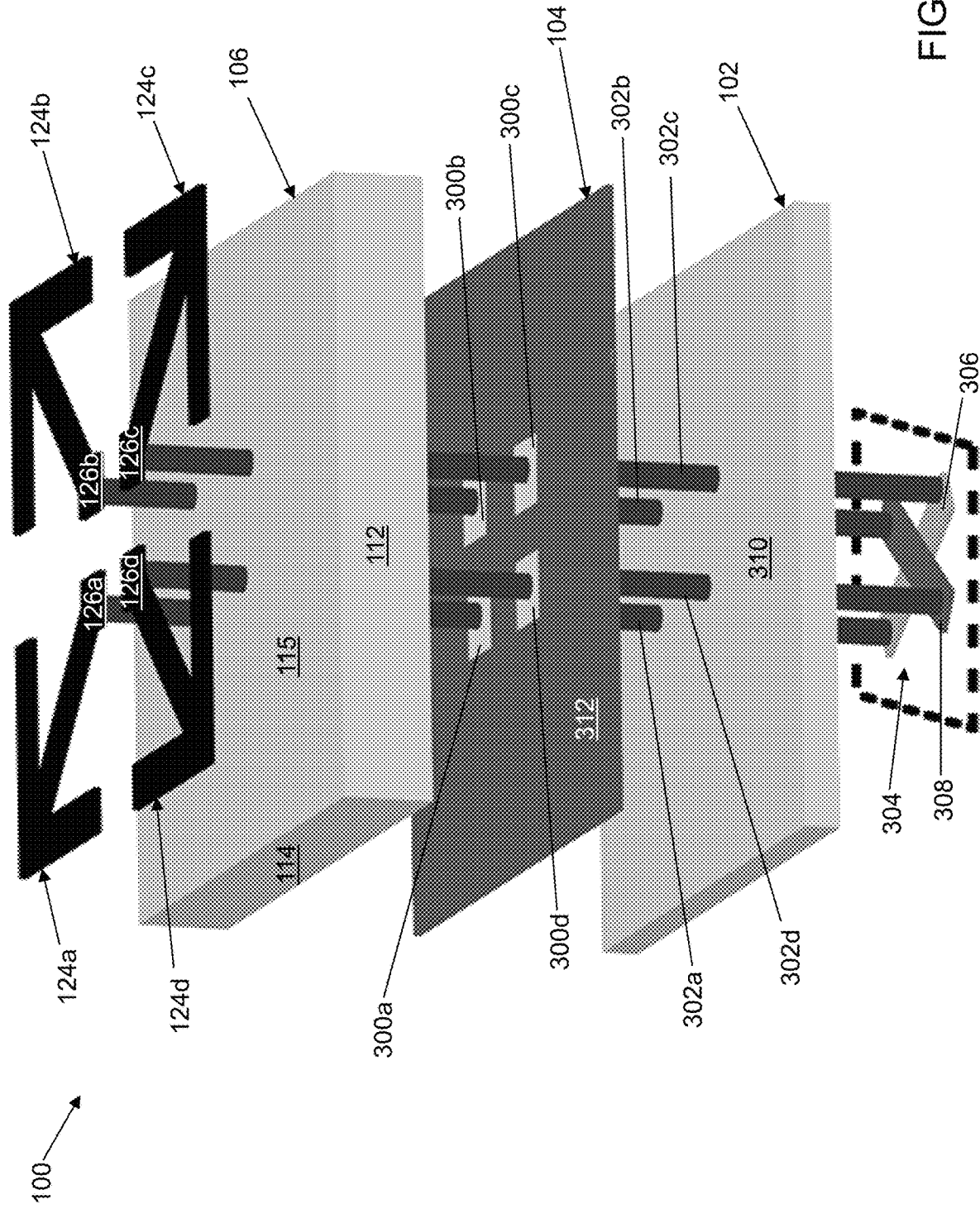
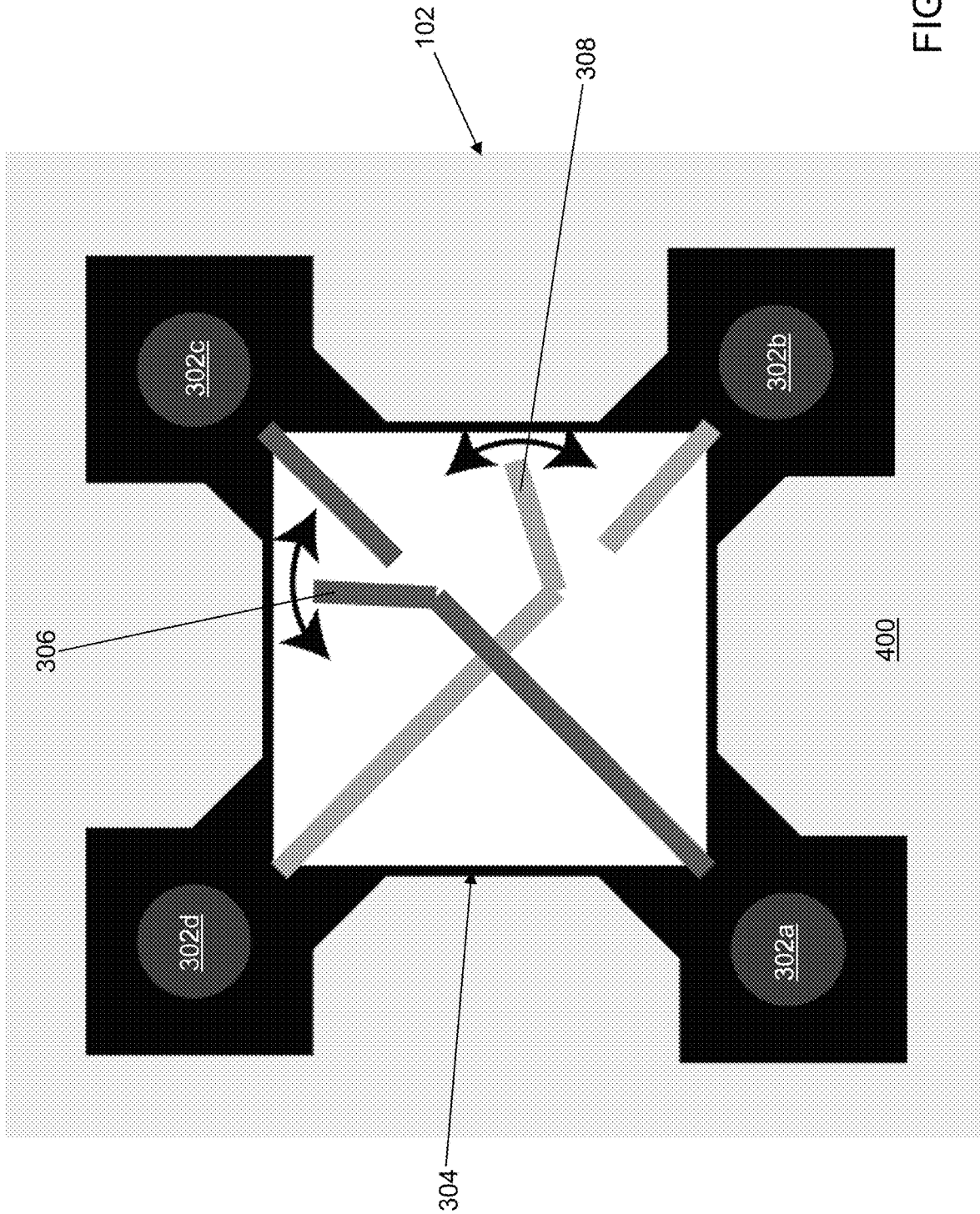


FIG. 3



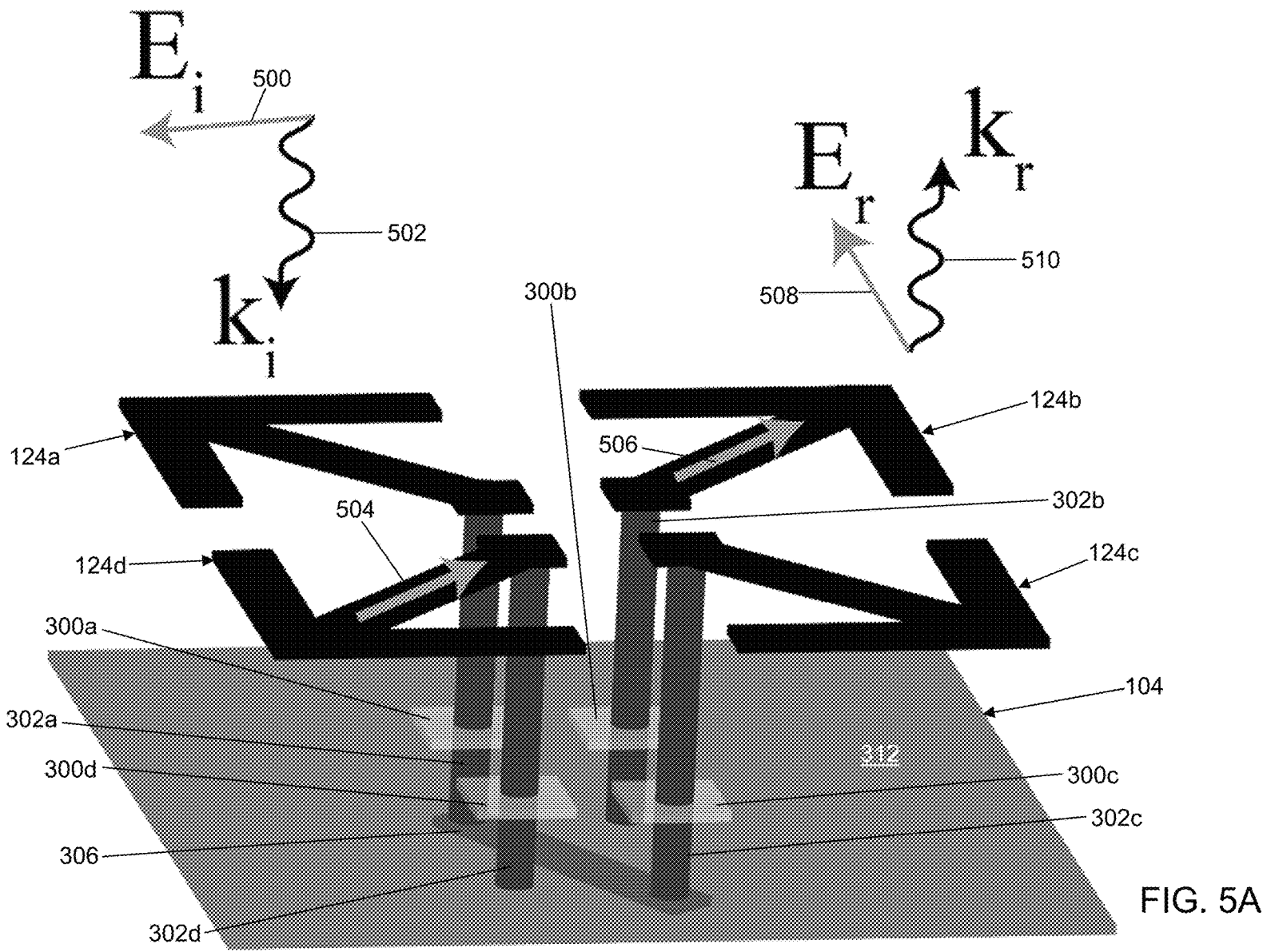
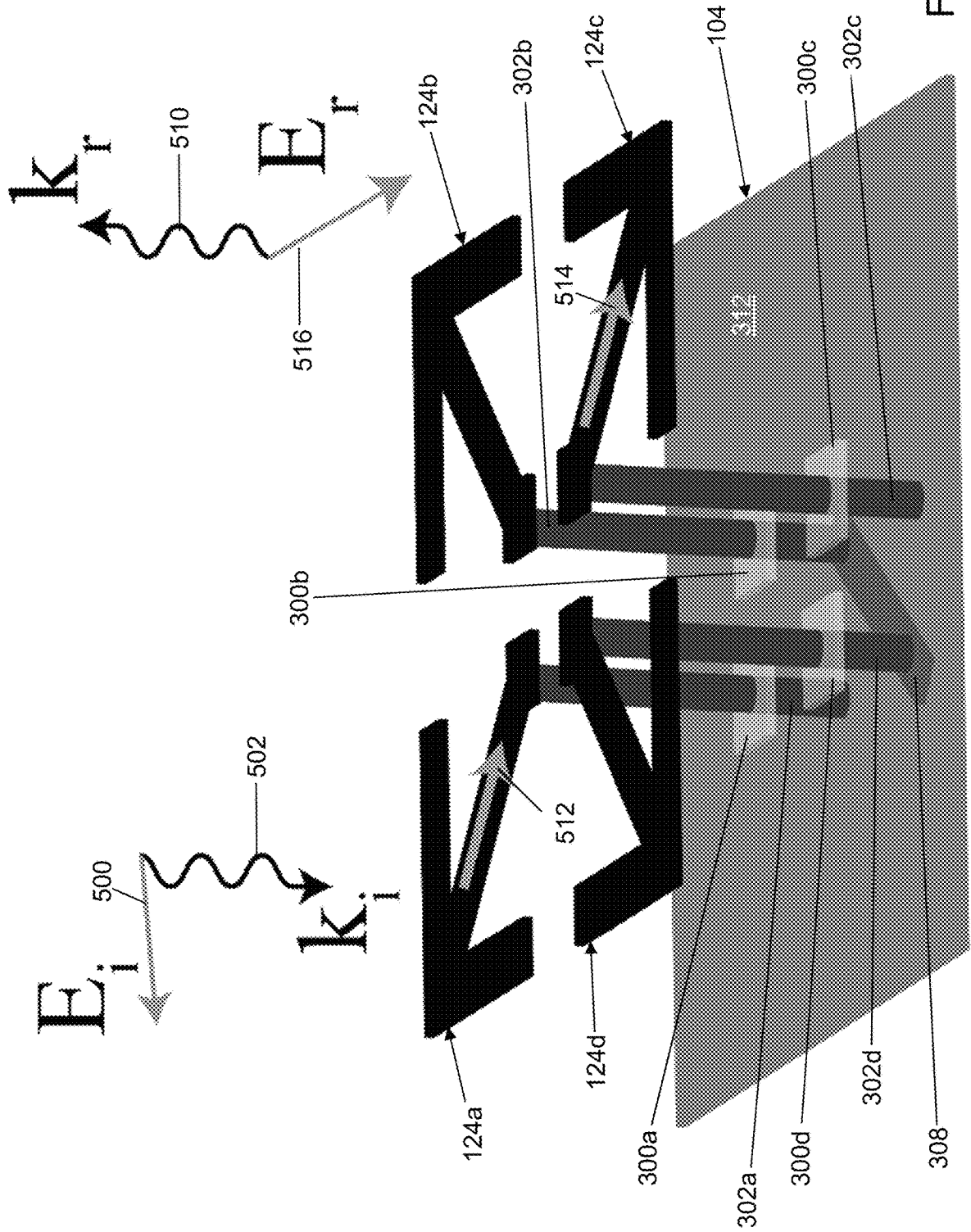


FIG. 5A



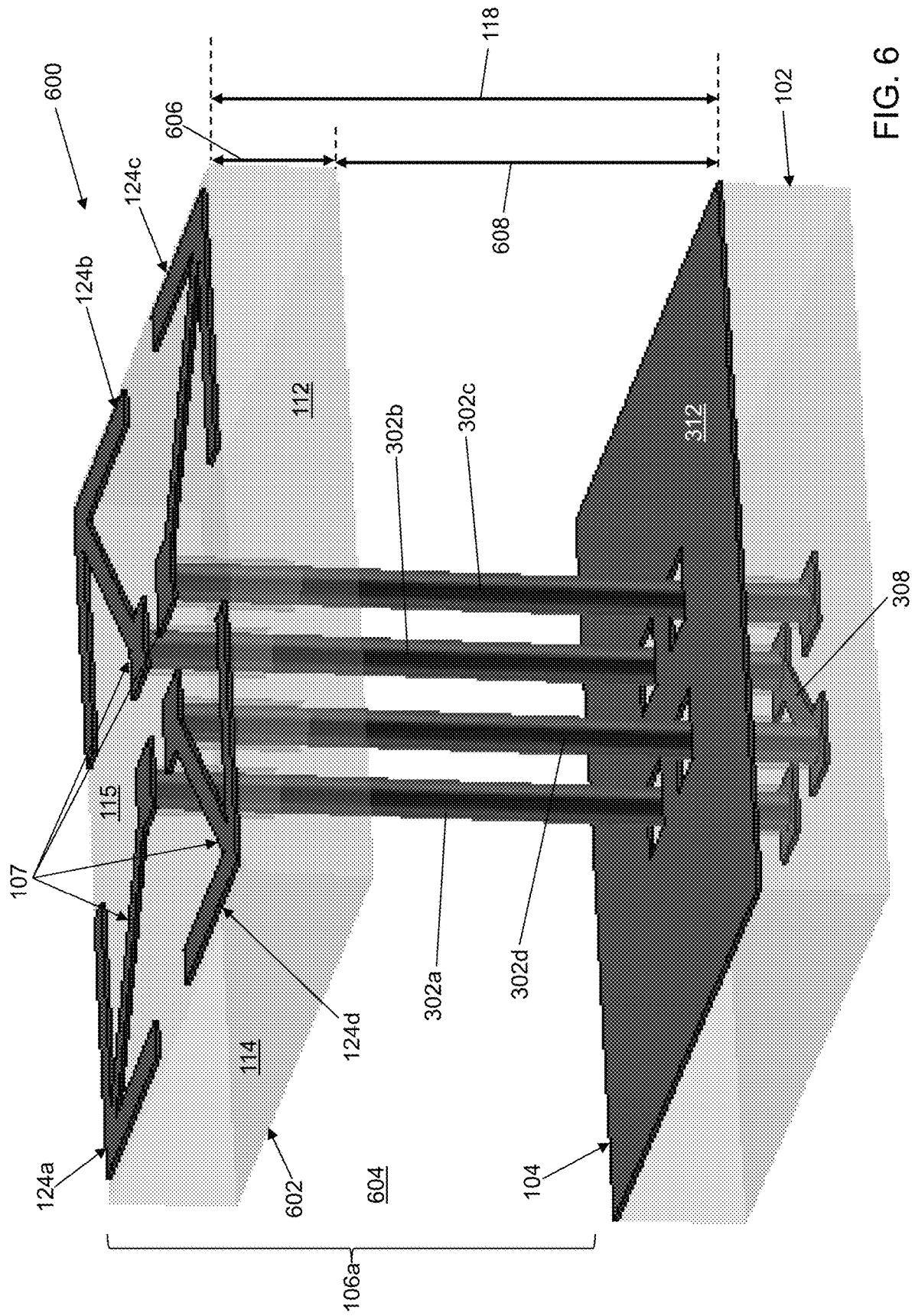


FIG. 6

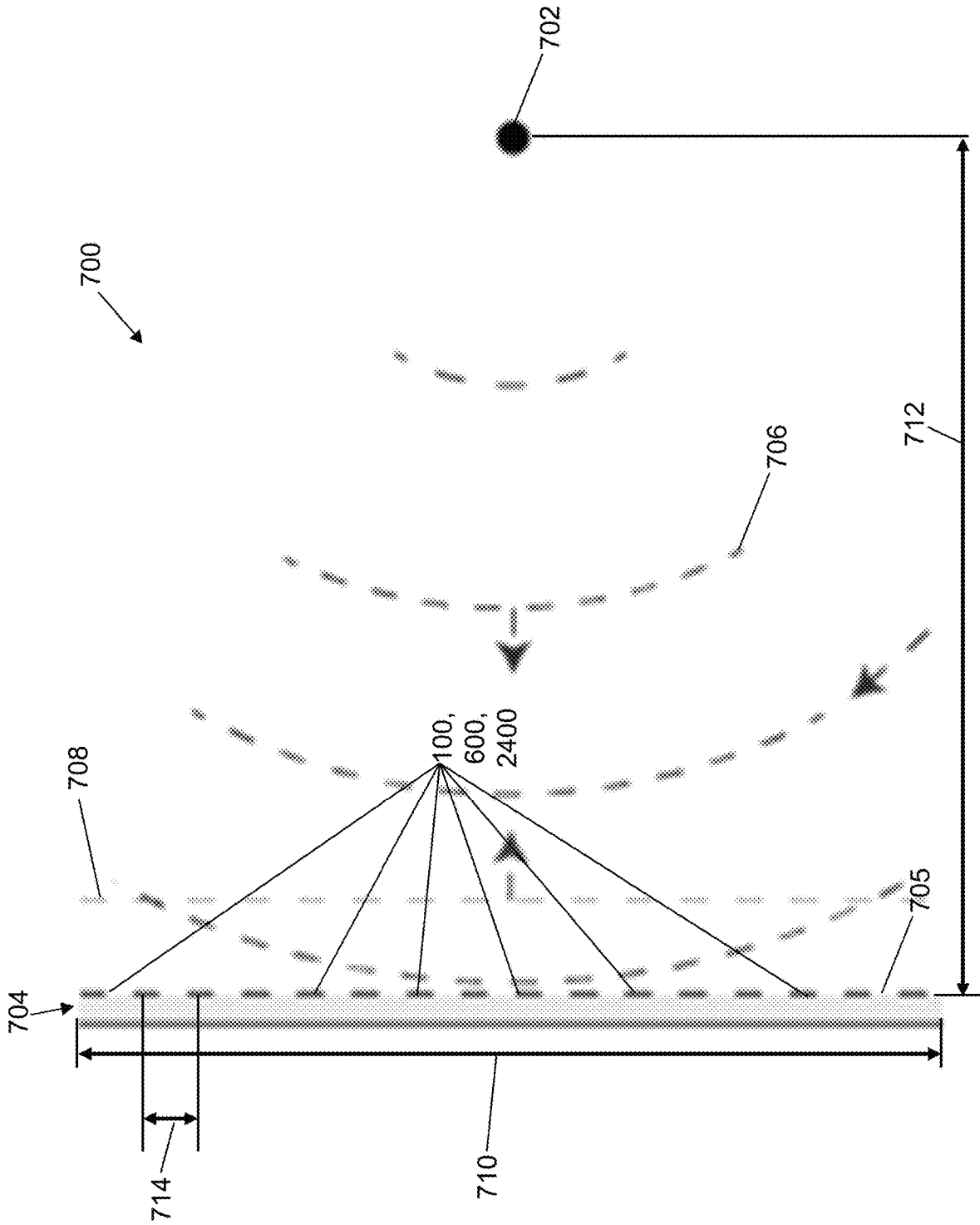


FIG. 7

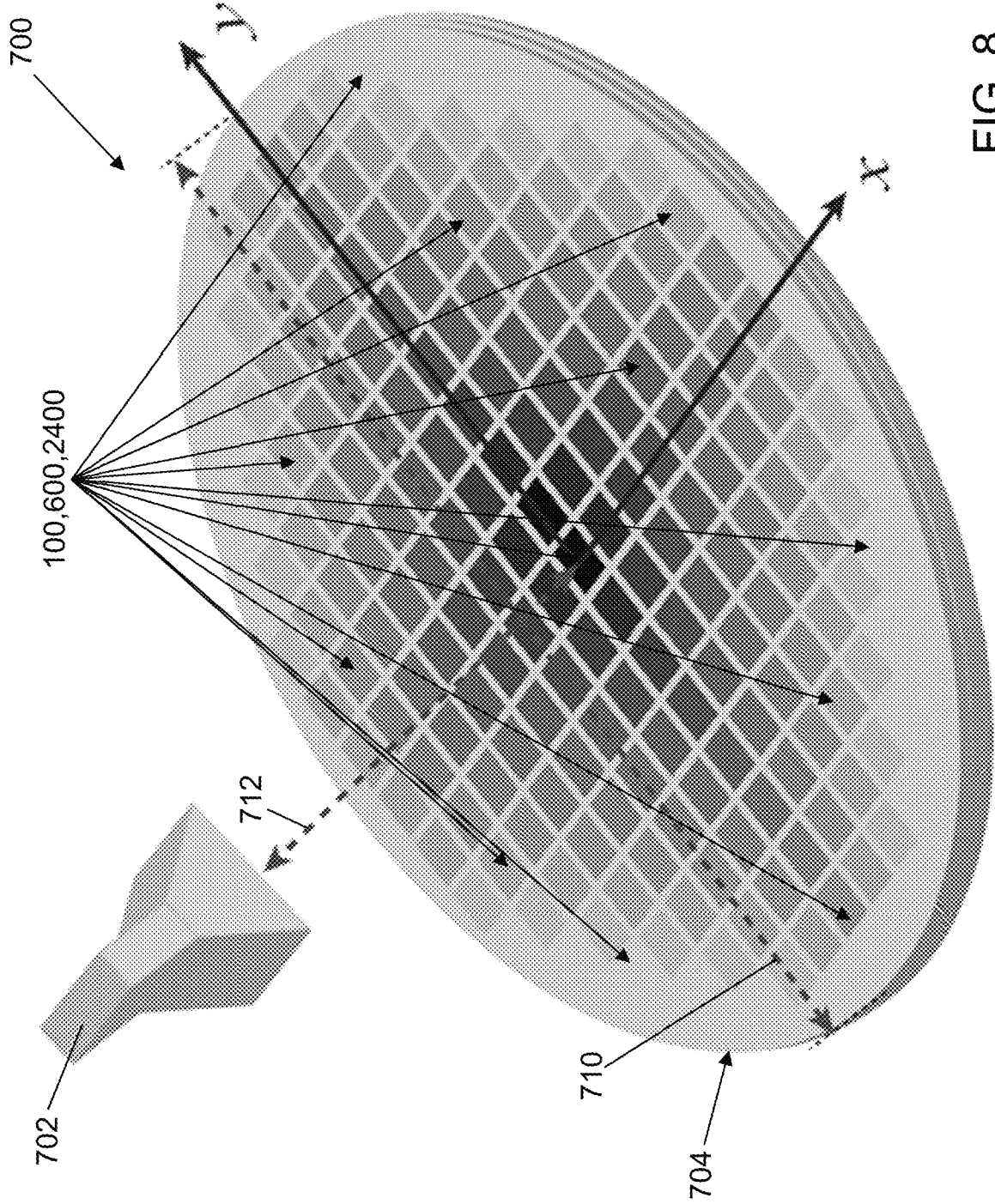


FIG. 8

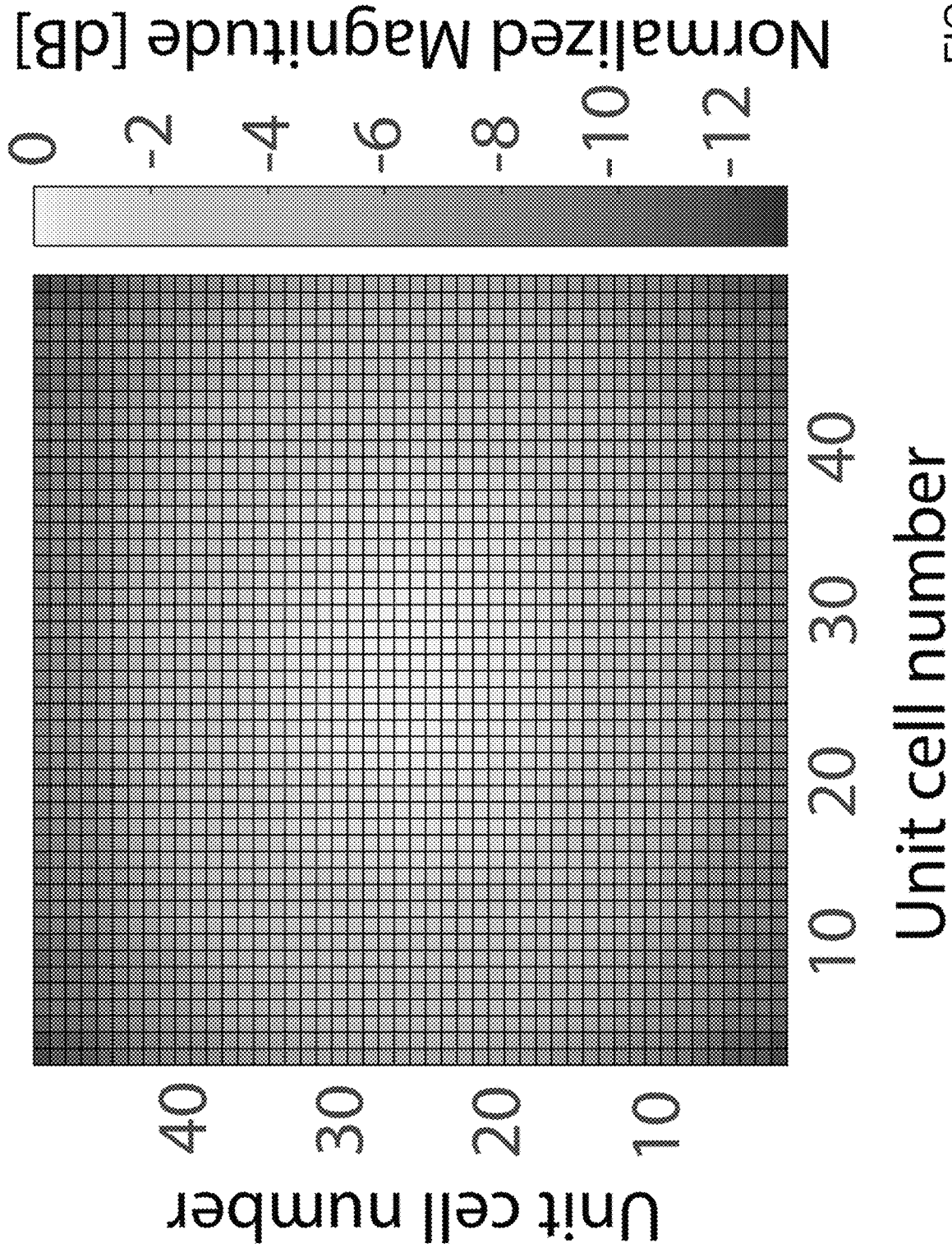


FIG. 9

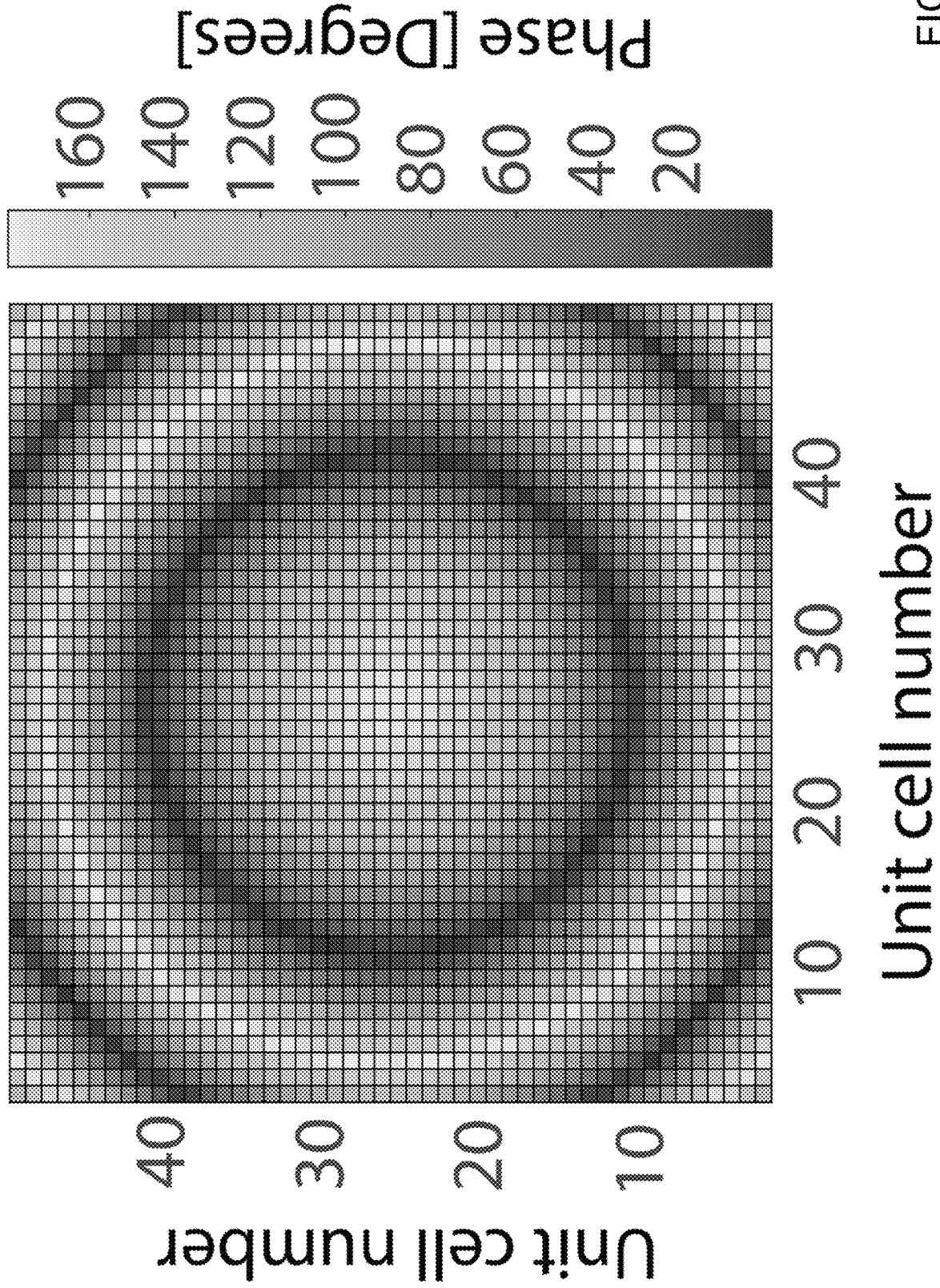


FIG. 10

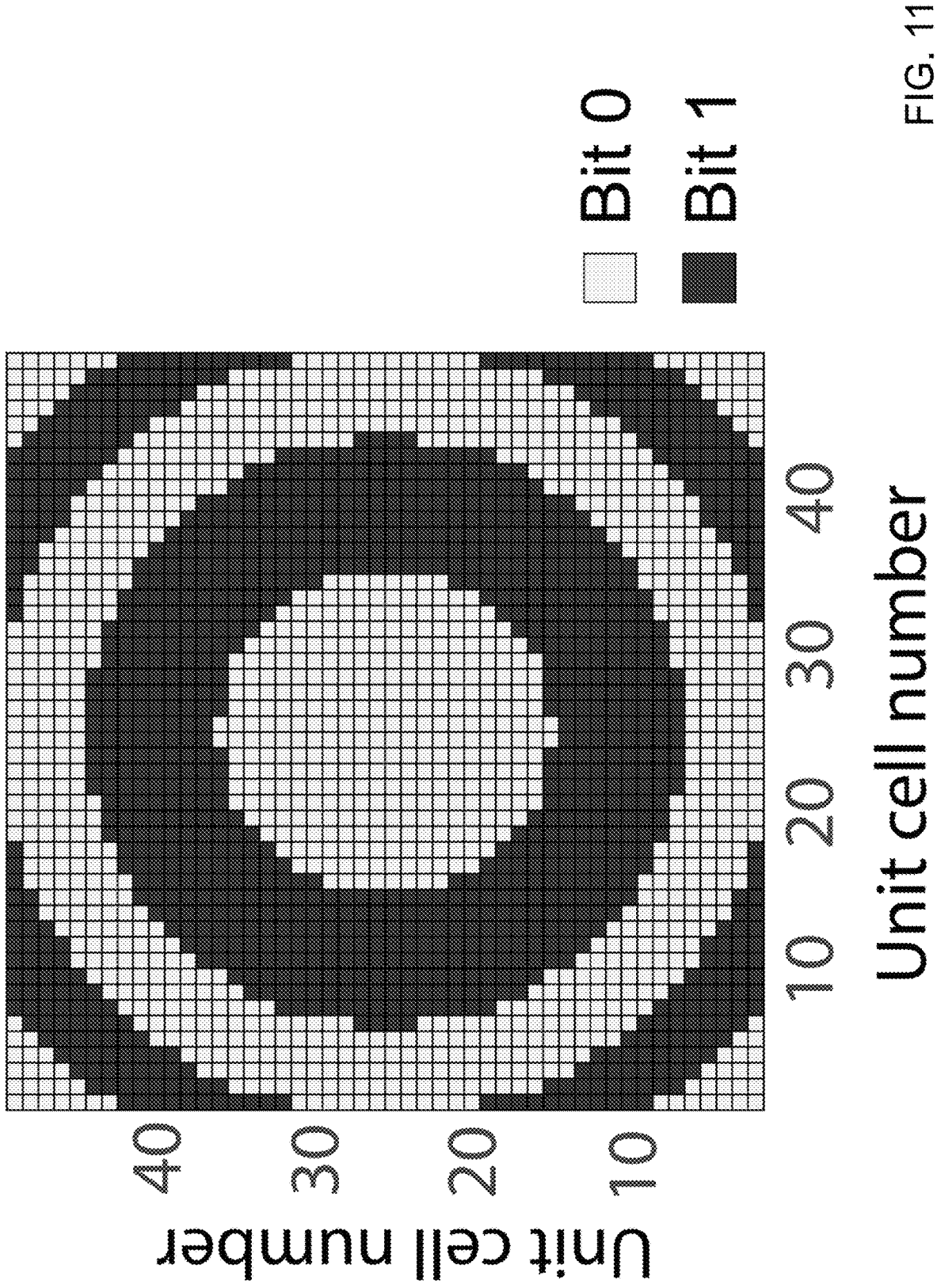


FIG. 11

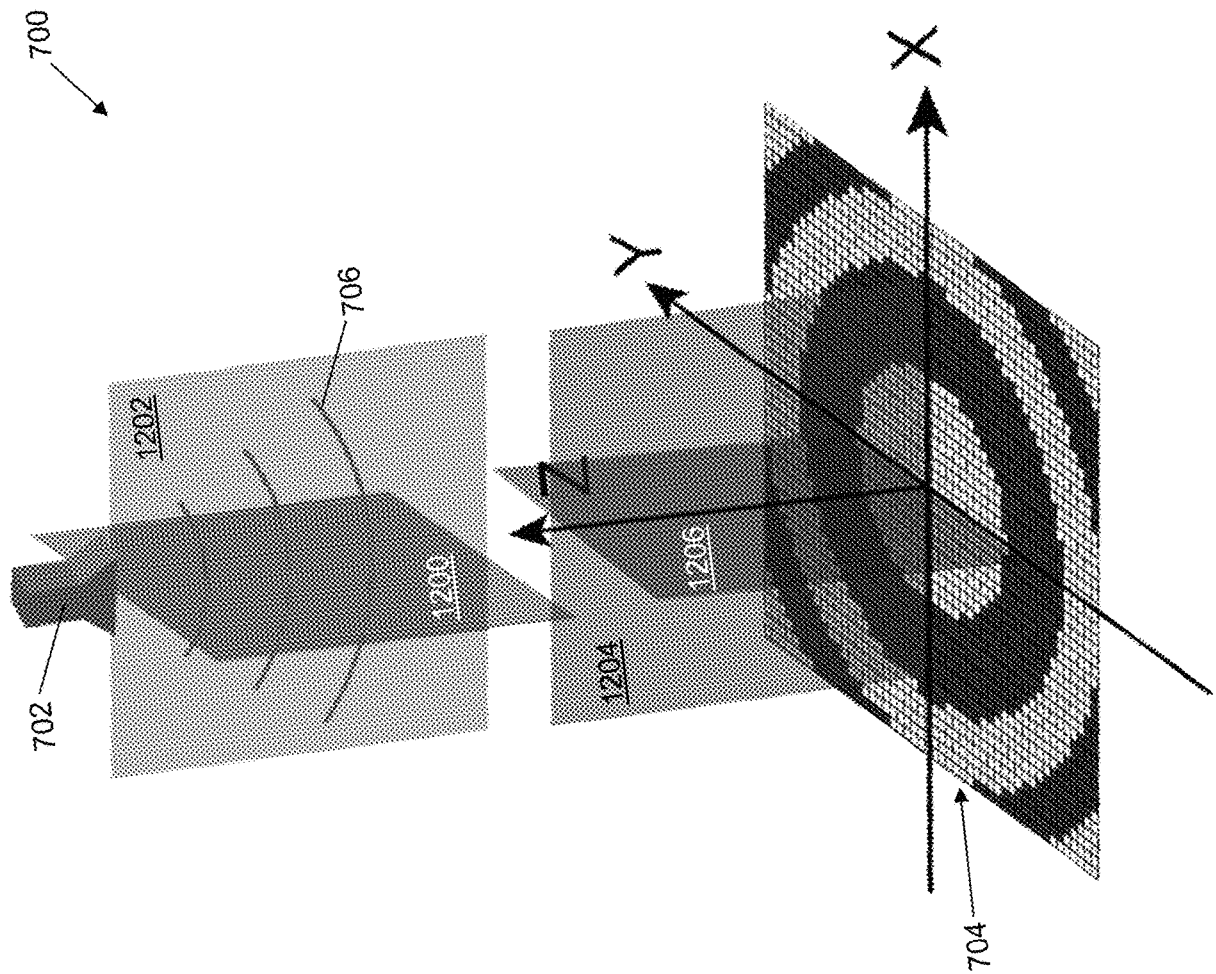


FIG. 12

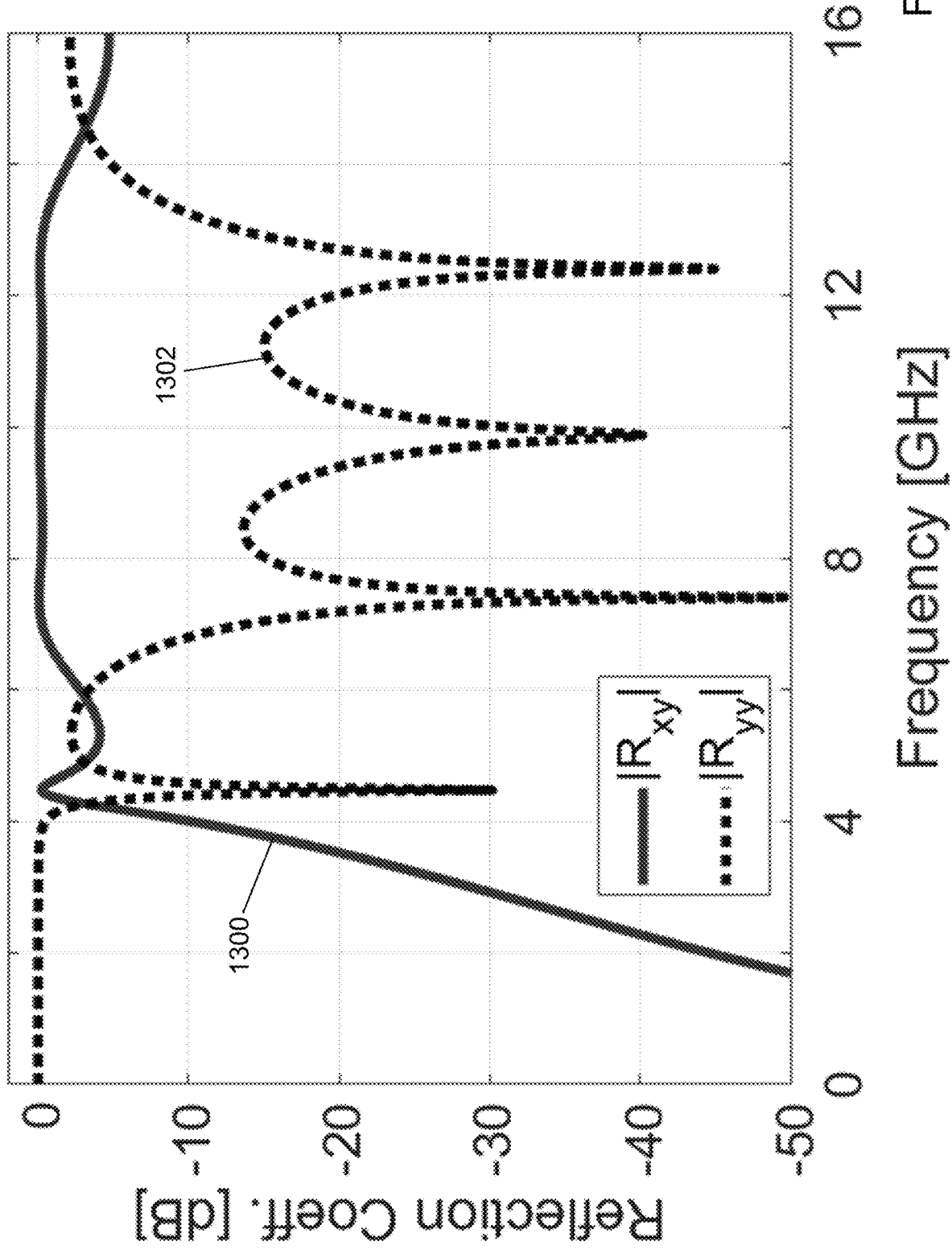


FIG. 13

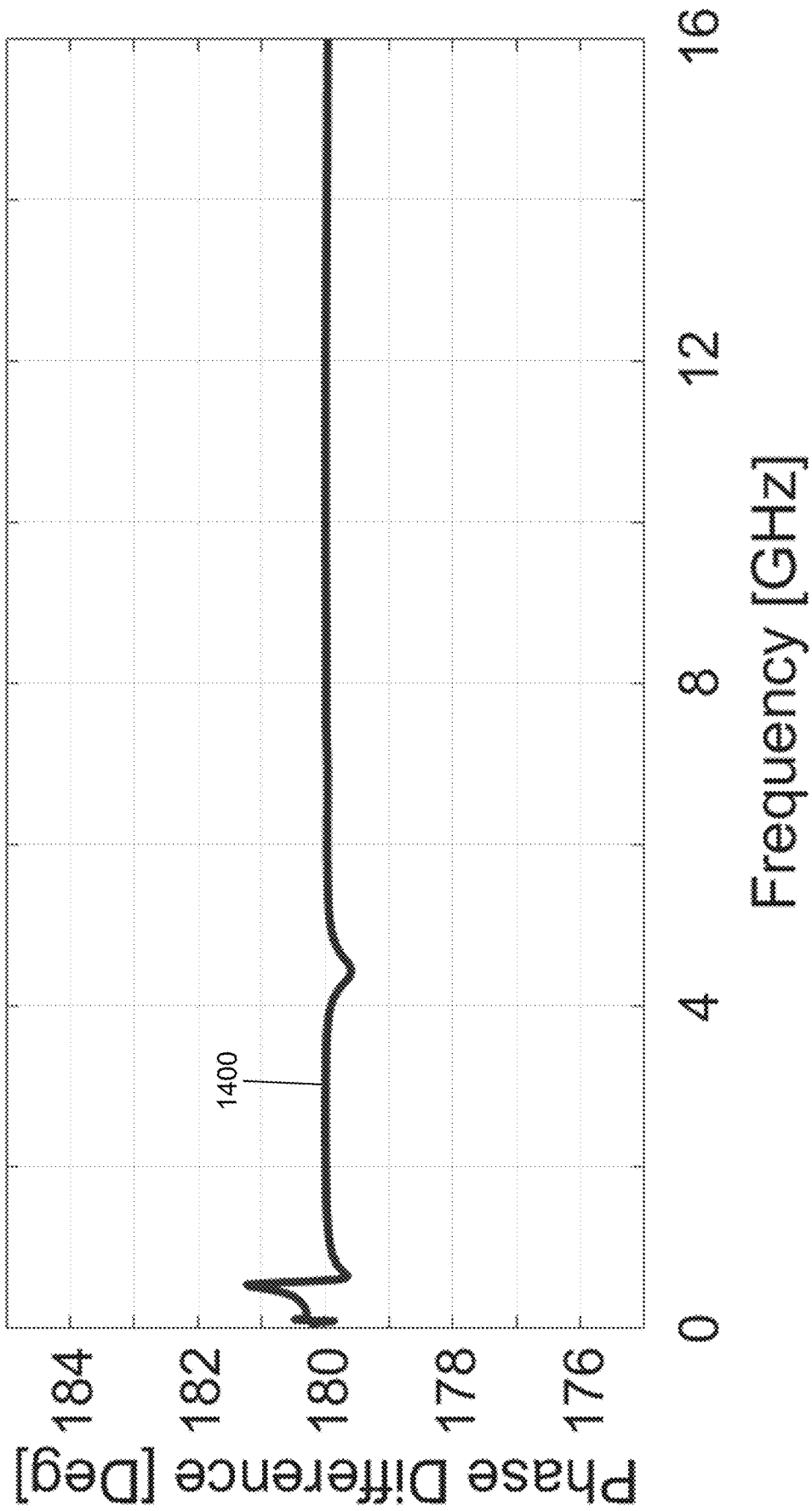


FIG. 14

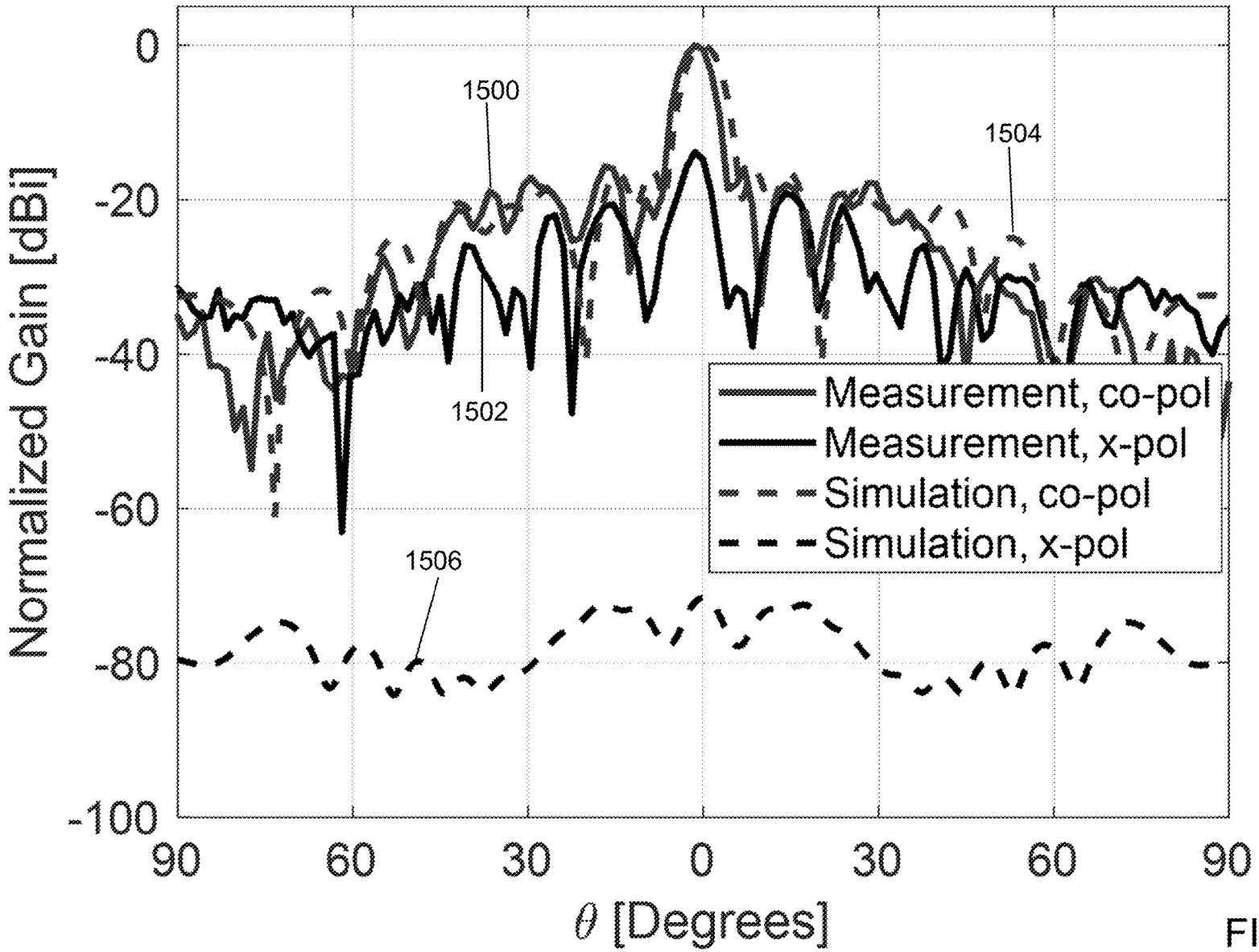


FIG. 15

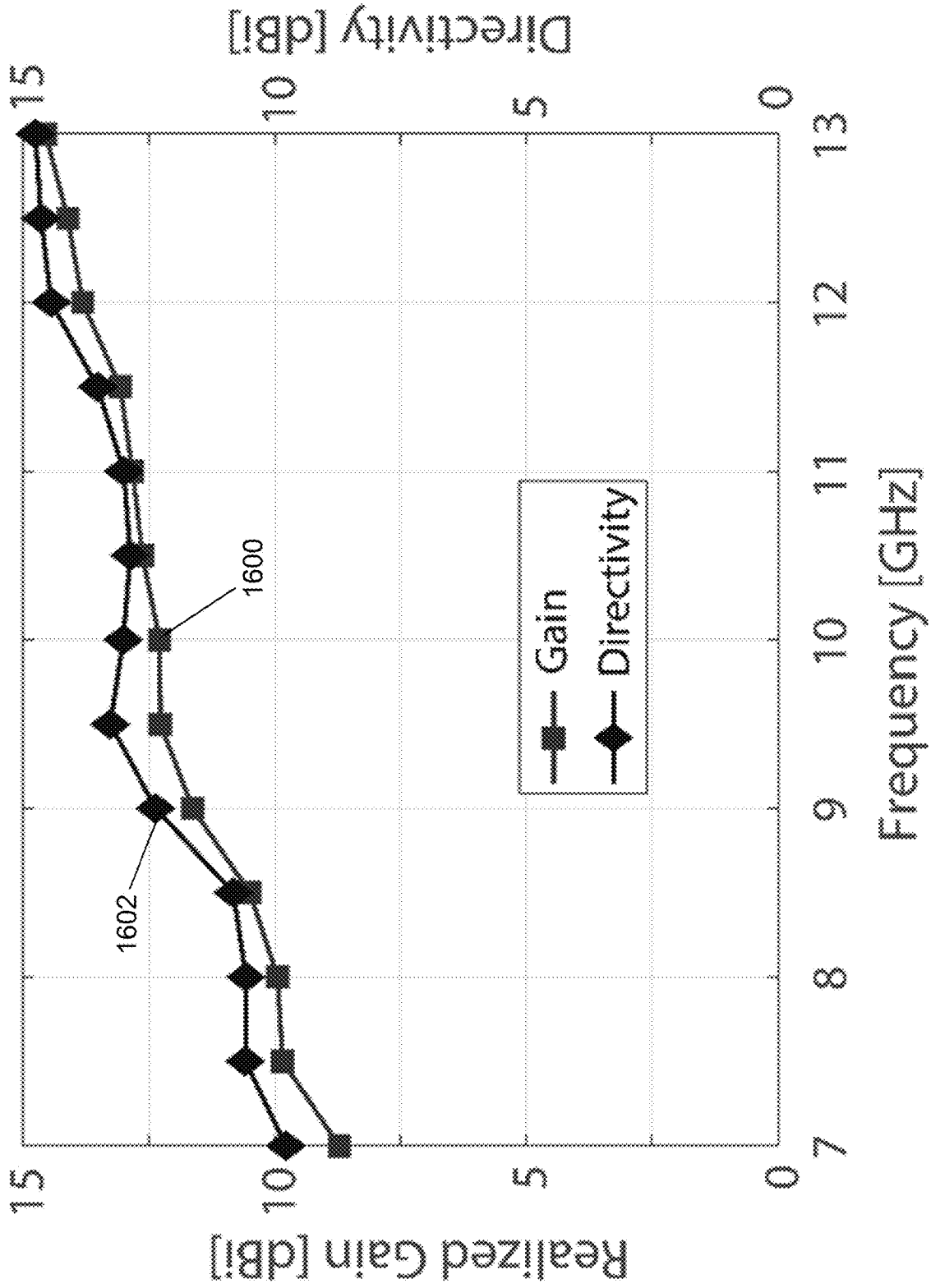


FIG. 16

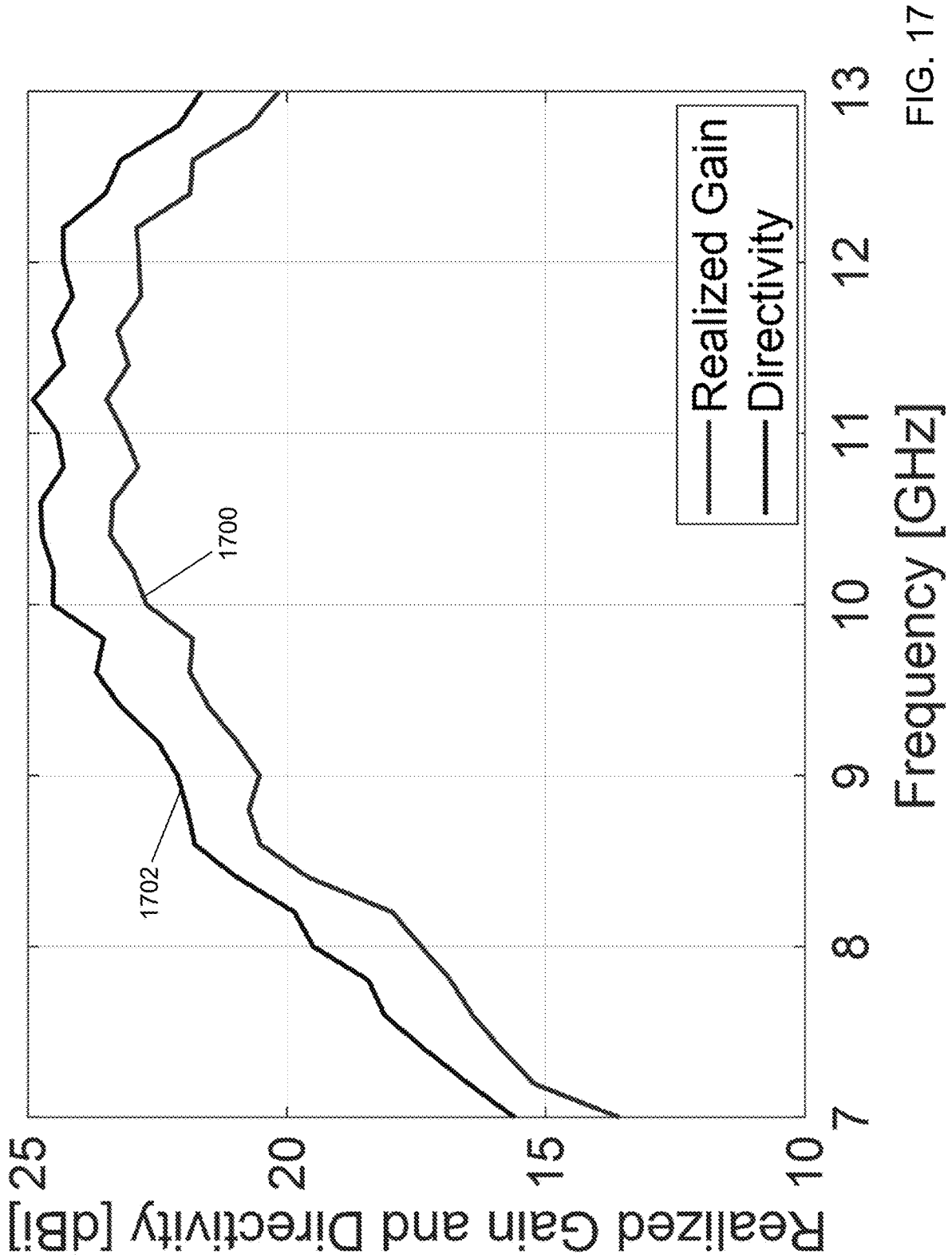


FIG. 17

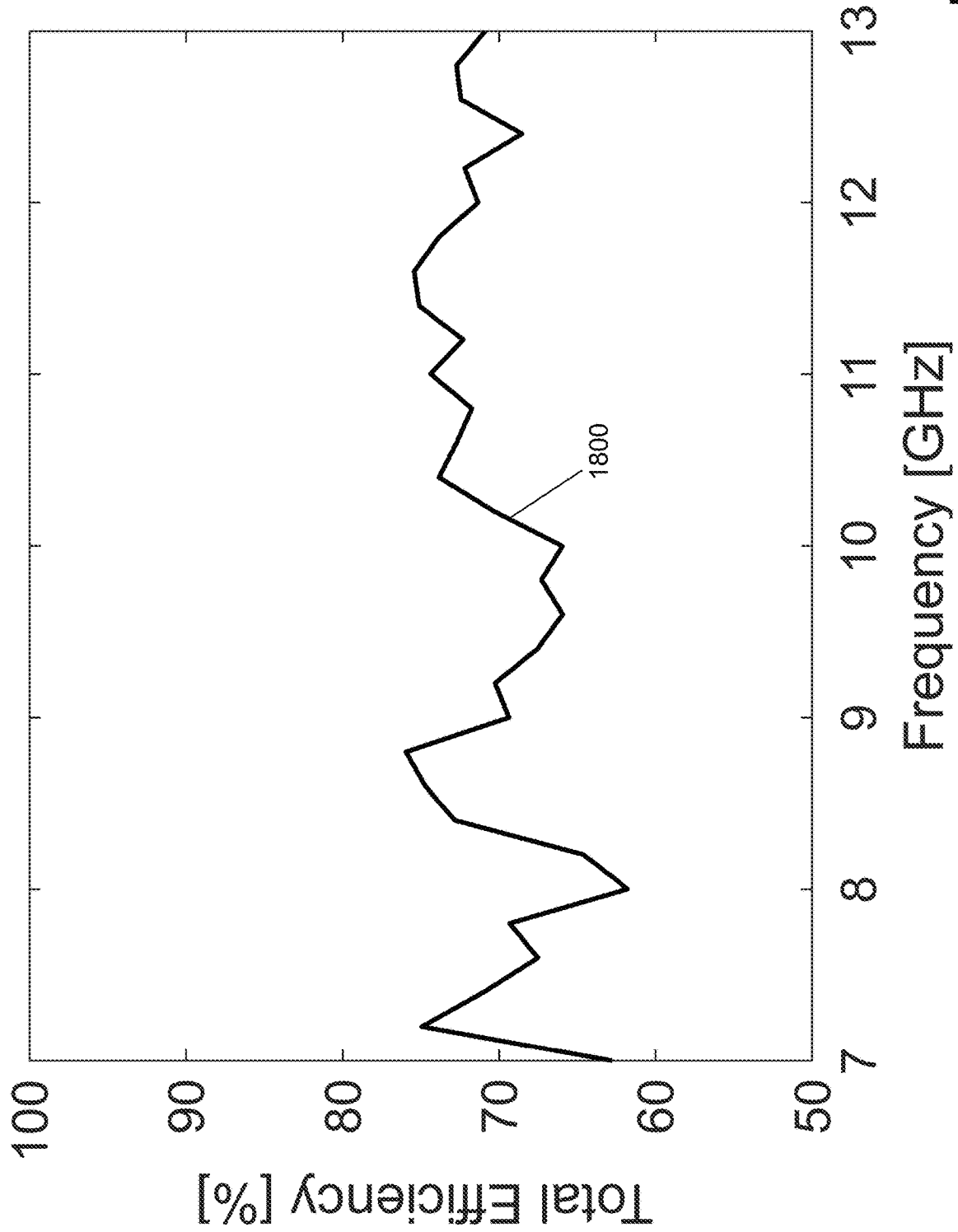
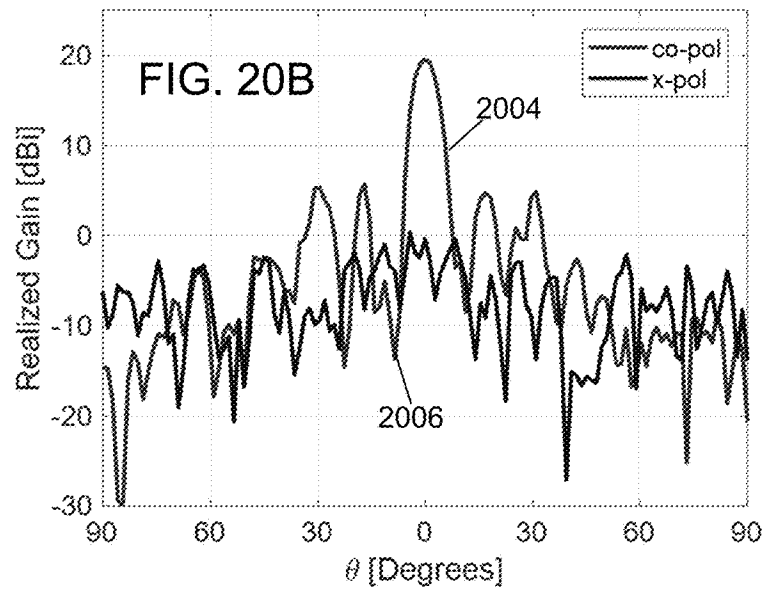
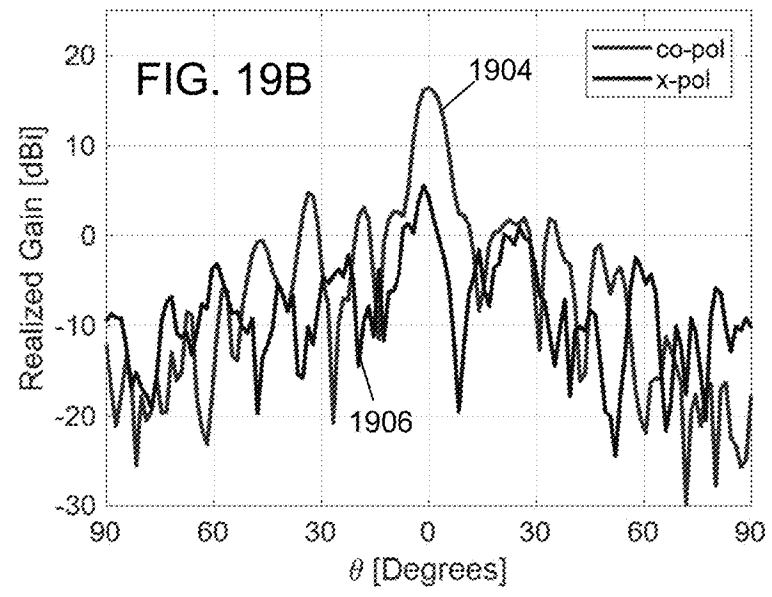
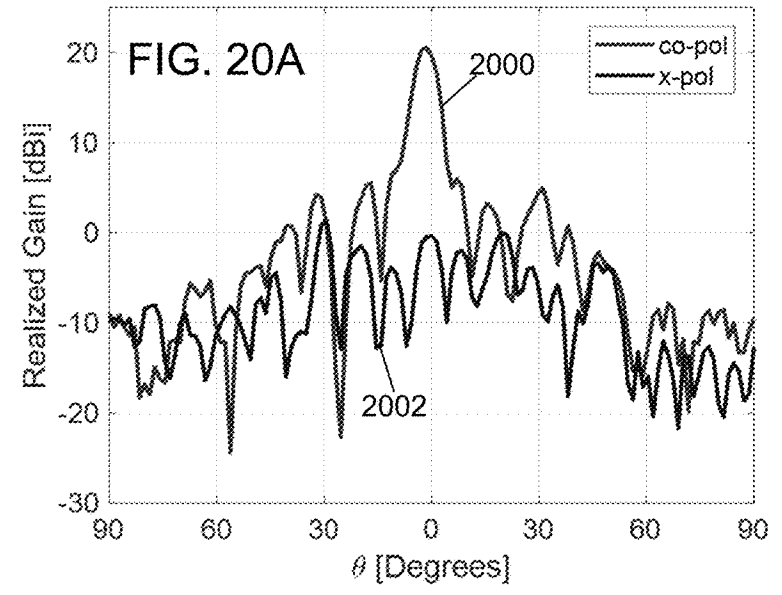
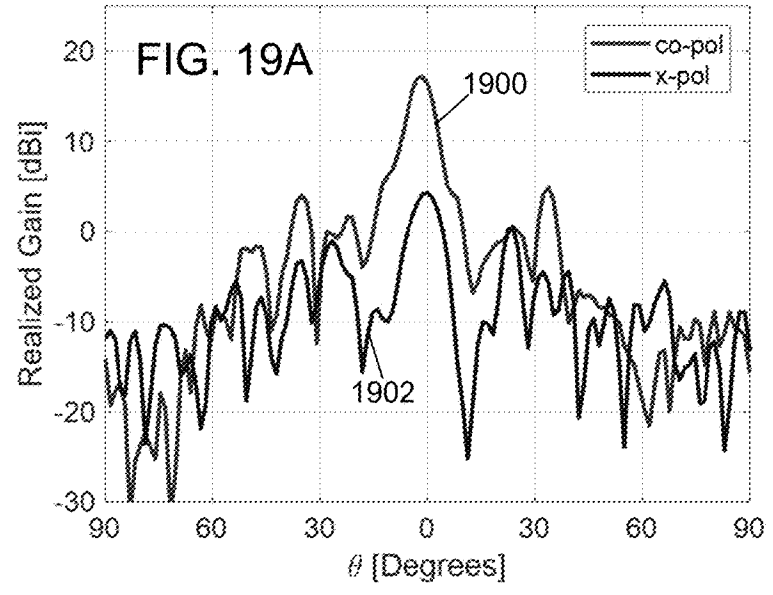


FIG. 18



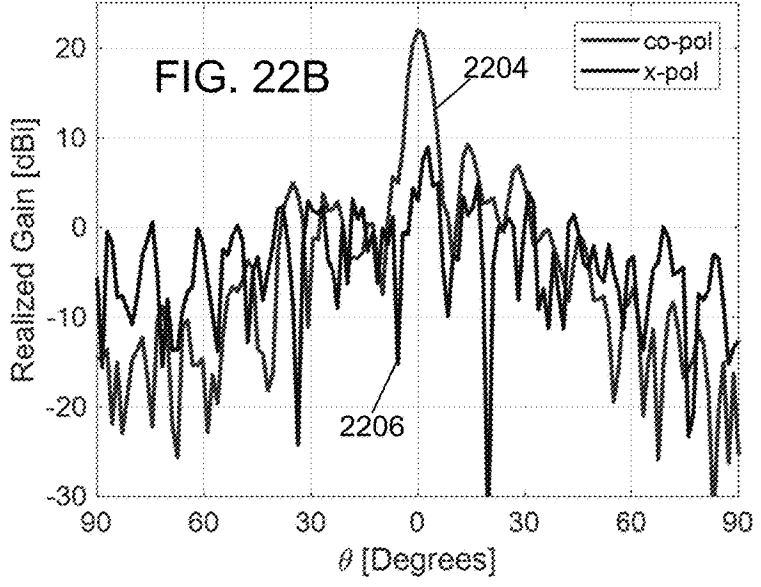
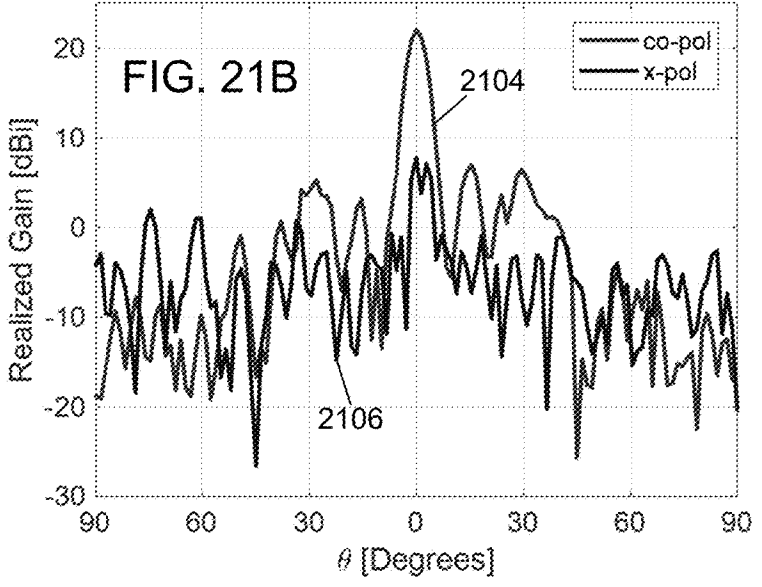
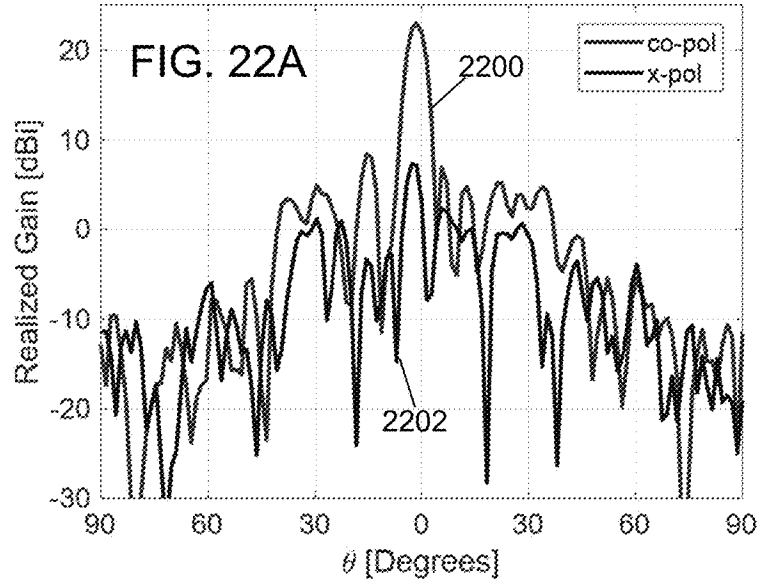
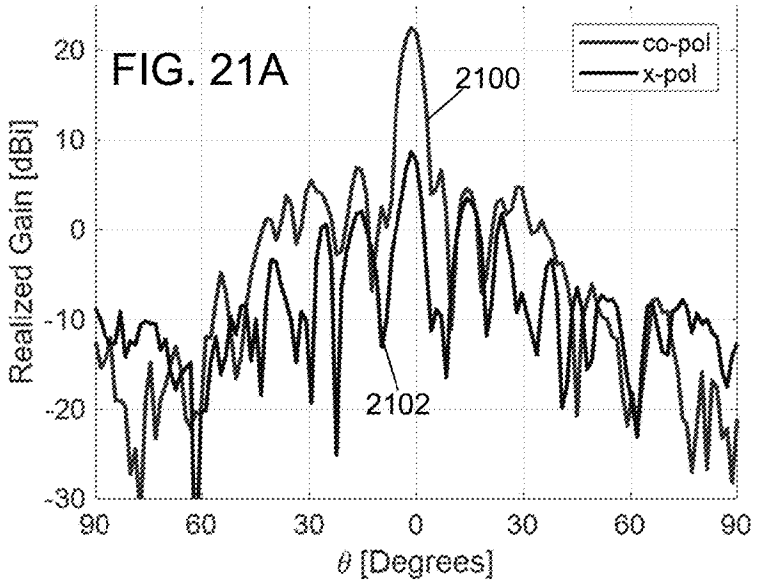


FIG. 23A

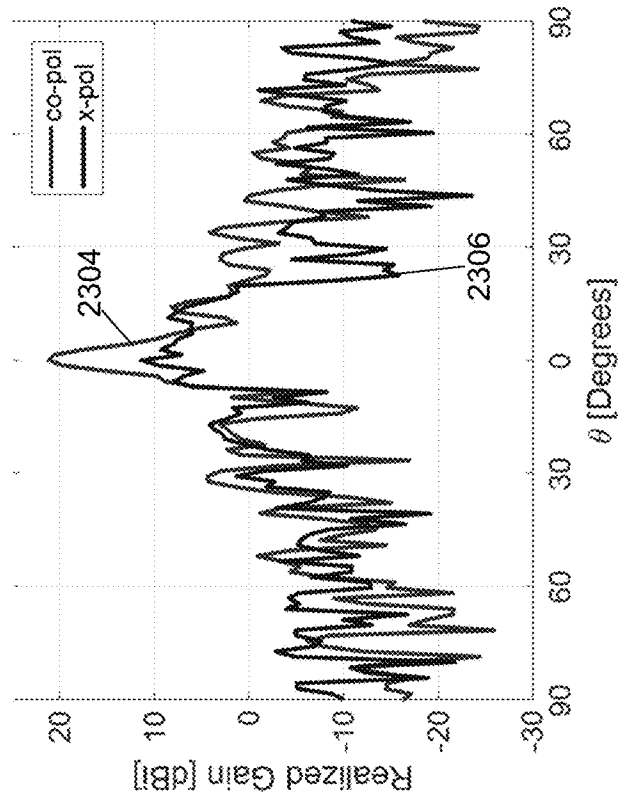
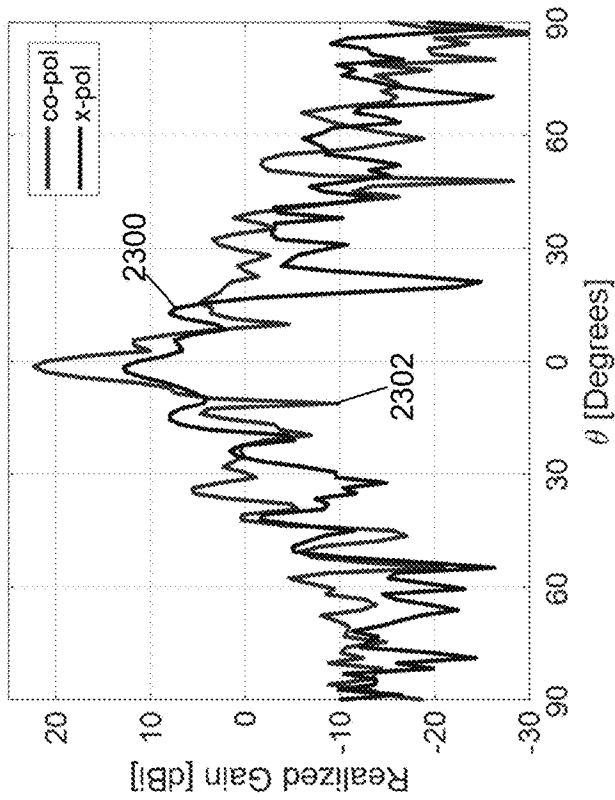


FIG. 23B

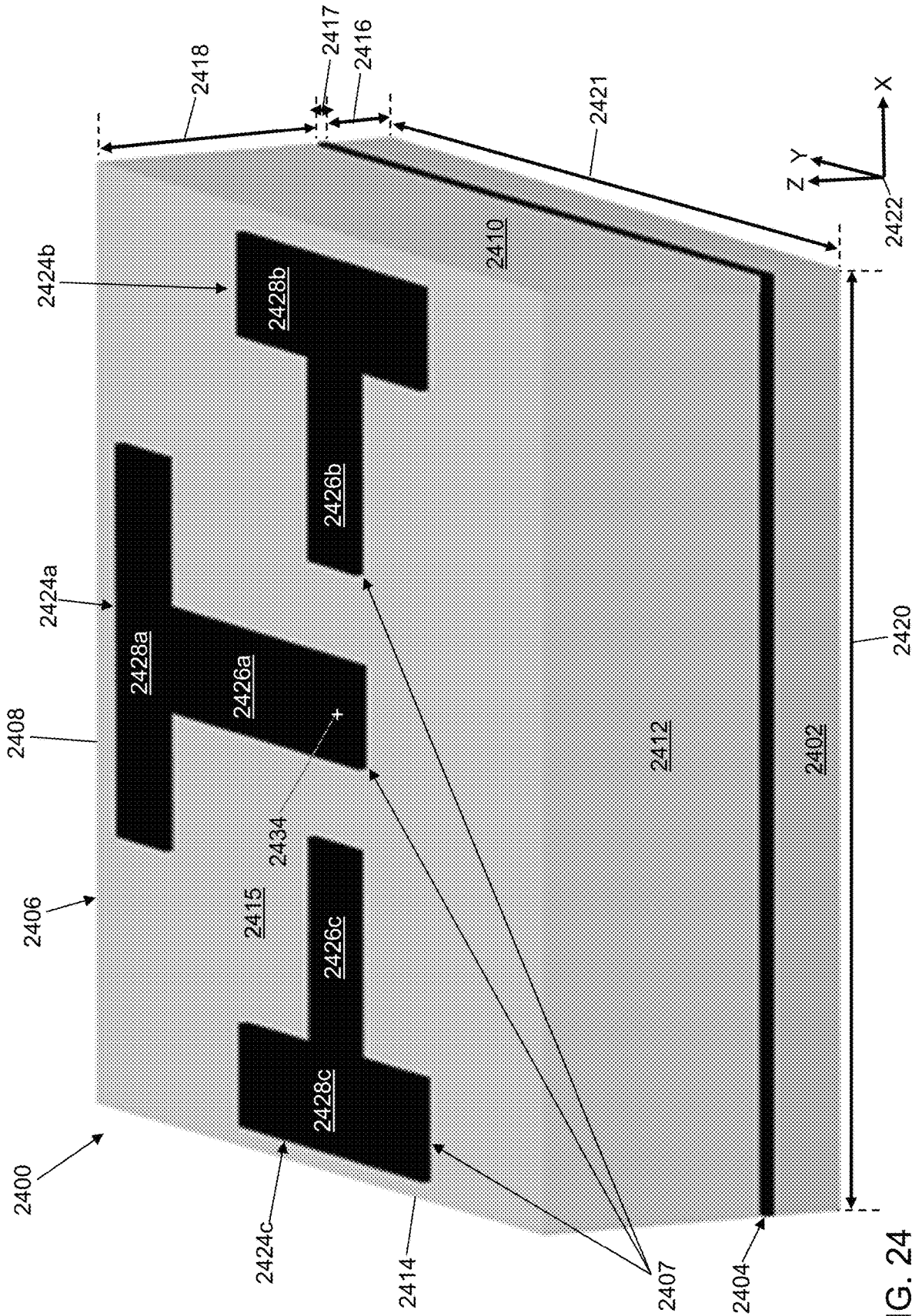


FIG. 24

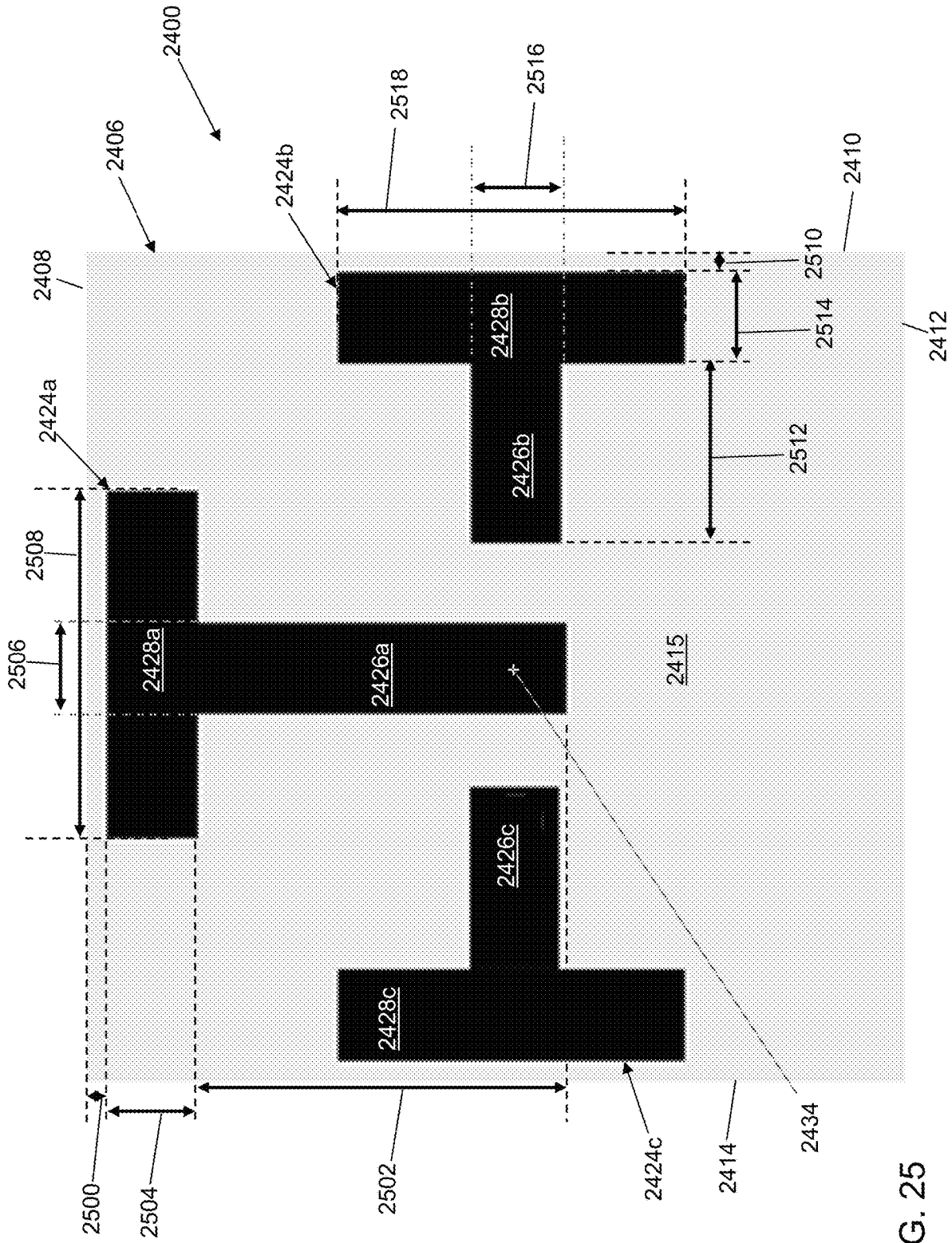


FIG. 25

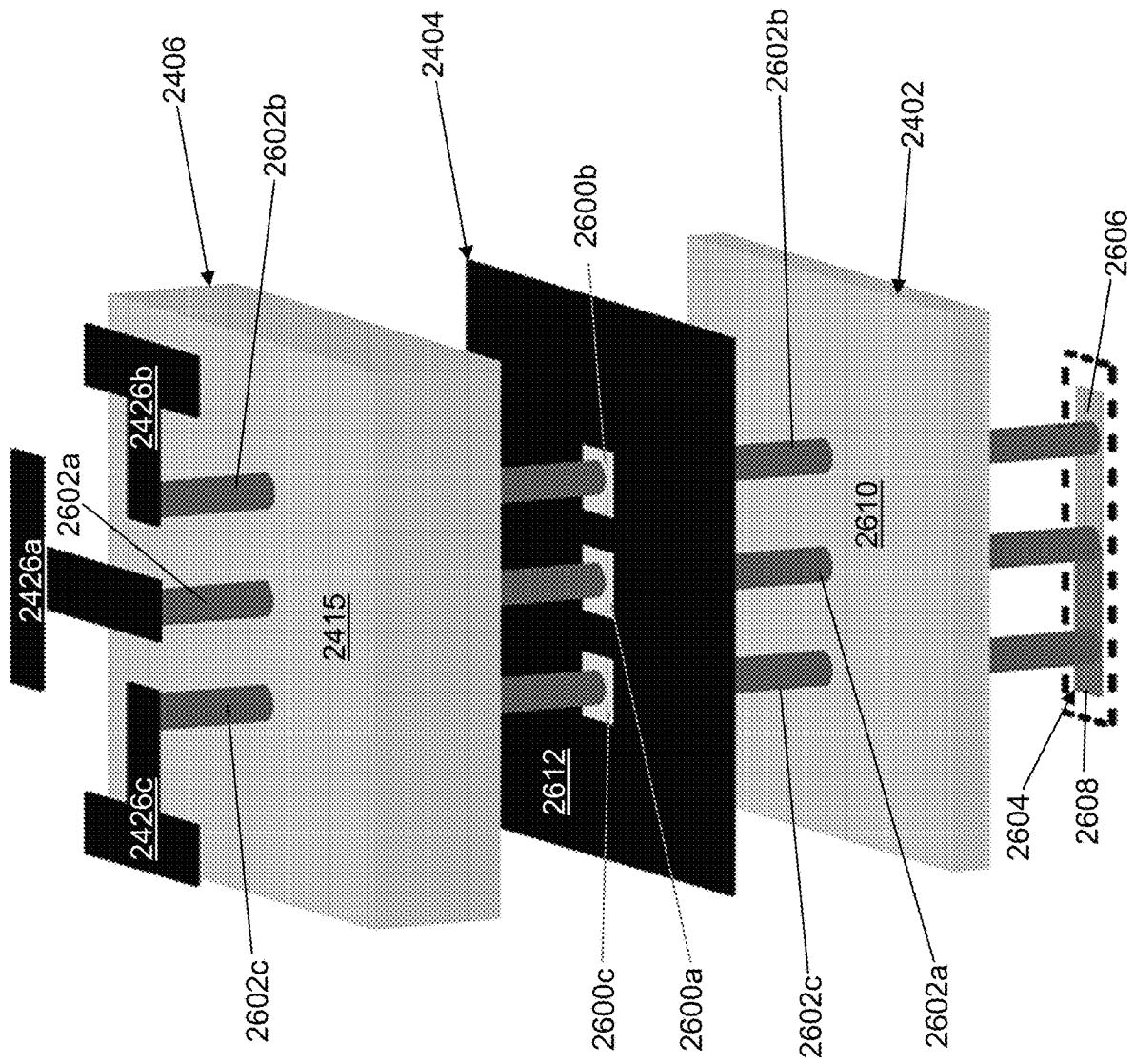


FIG. 26

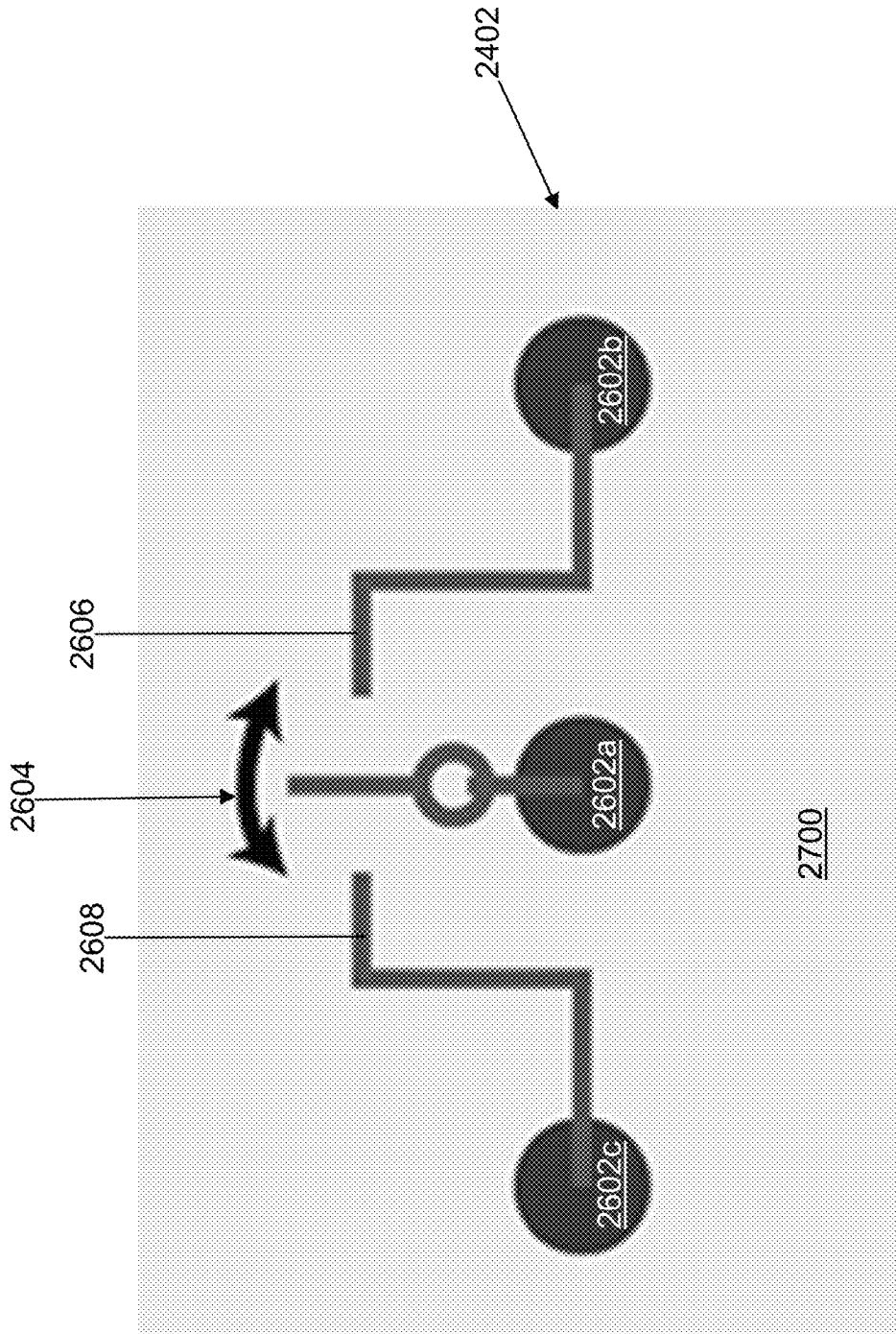


FIG. 27

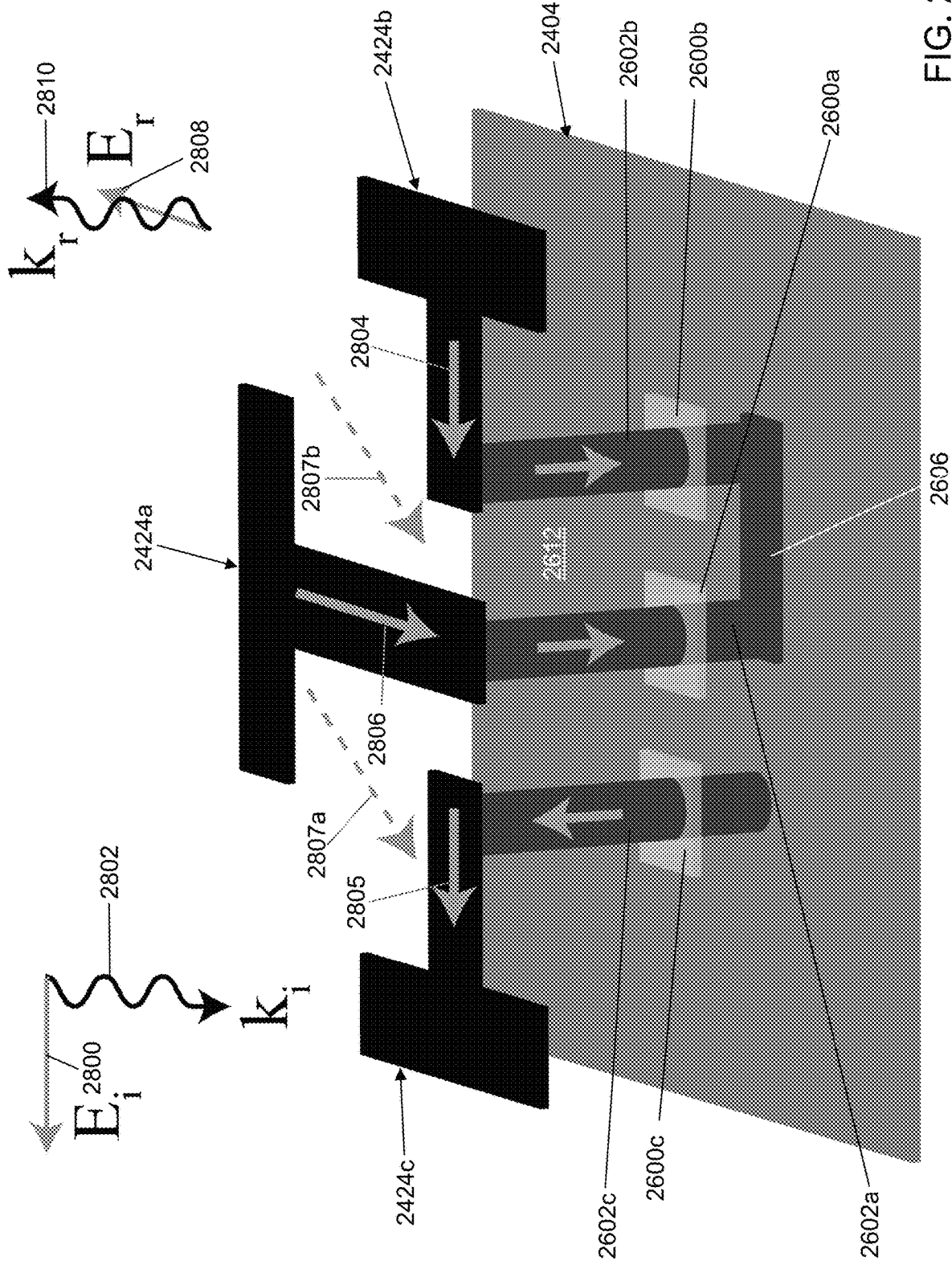


FIG. 28A

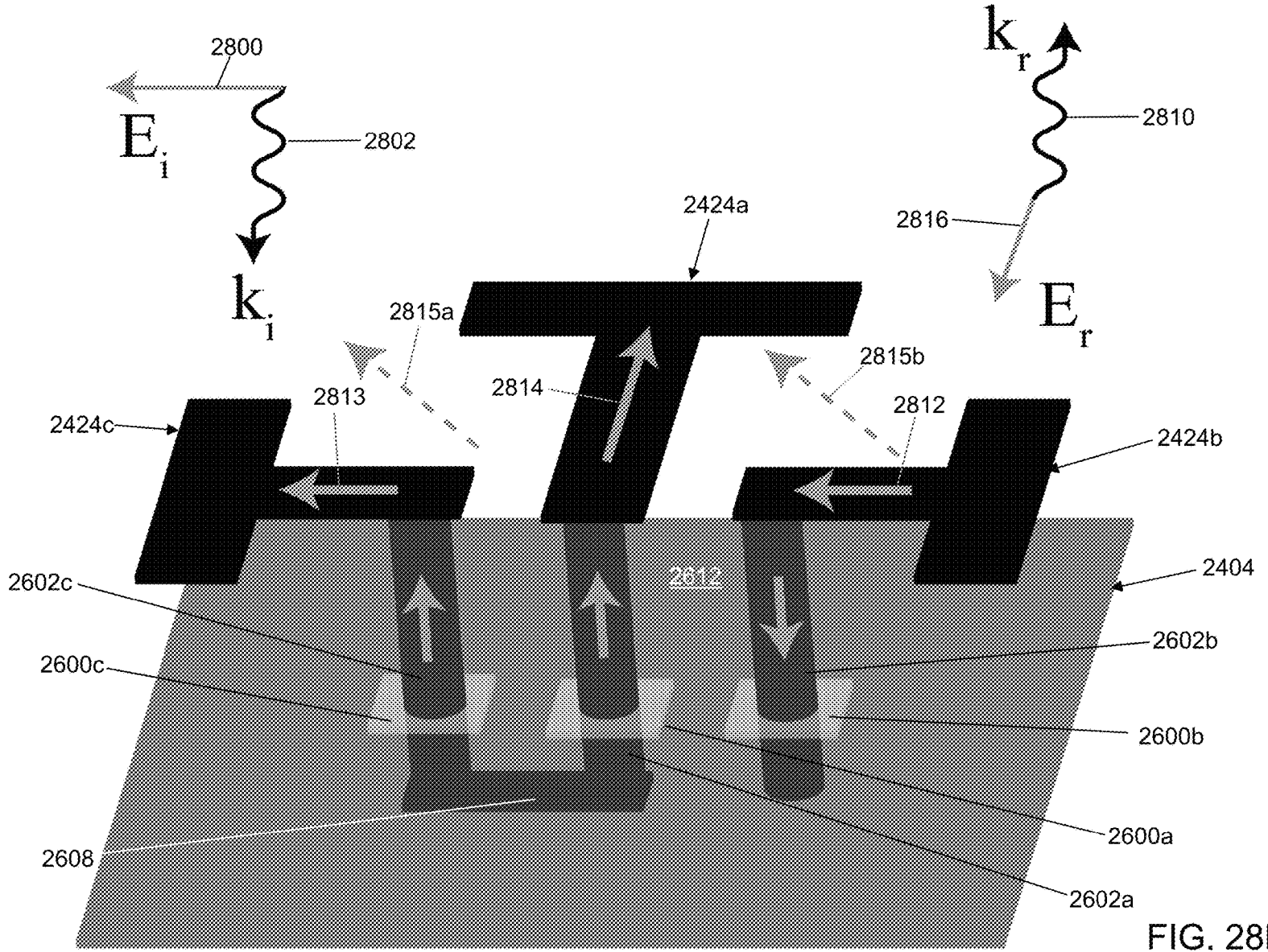


FIG. 28B

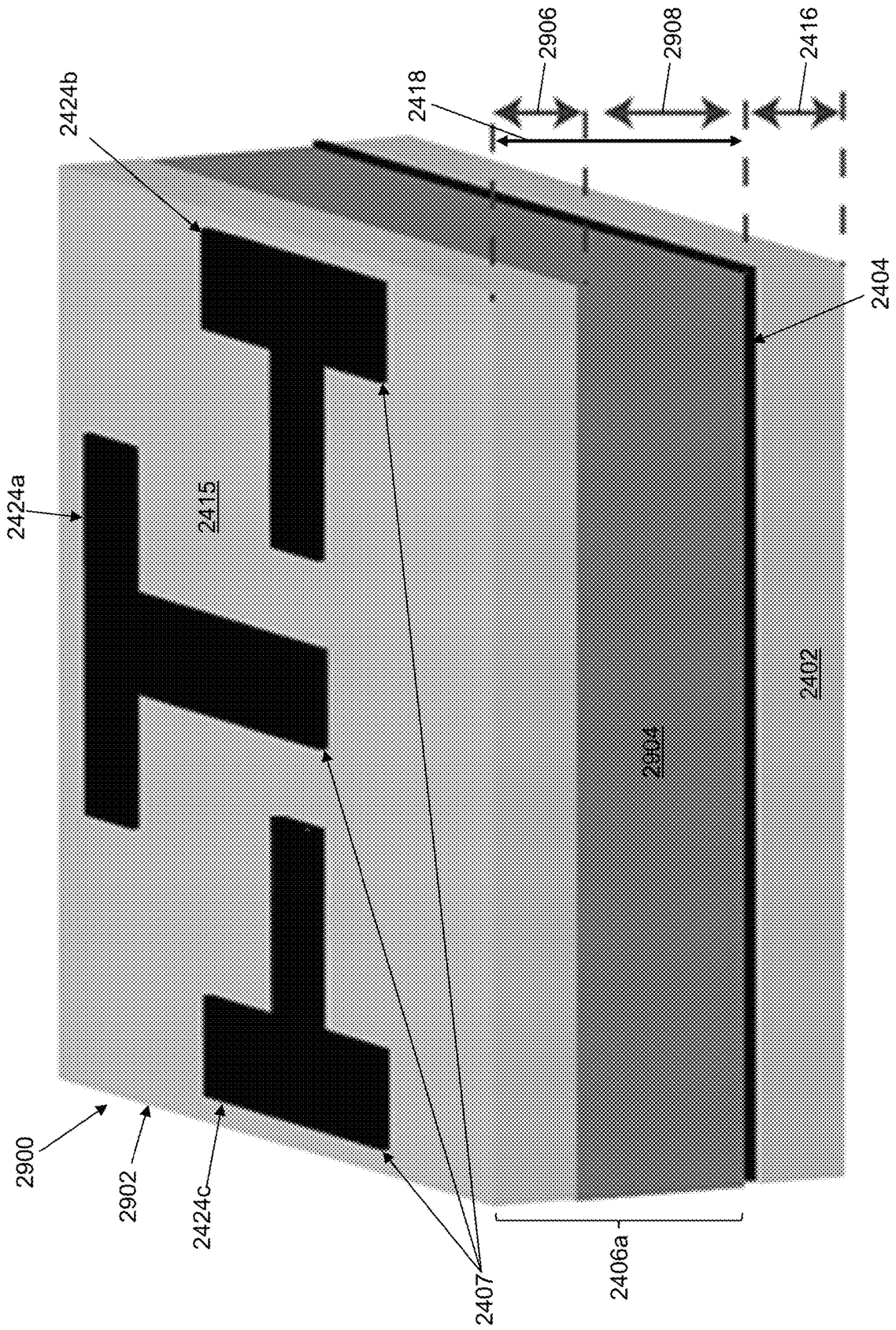


FIG. 29

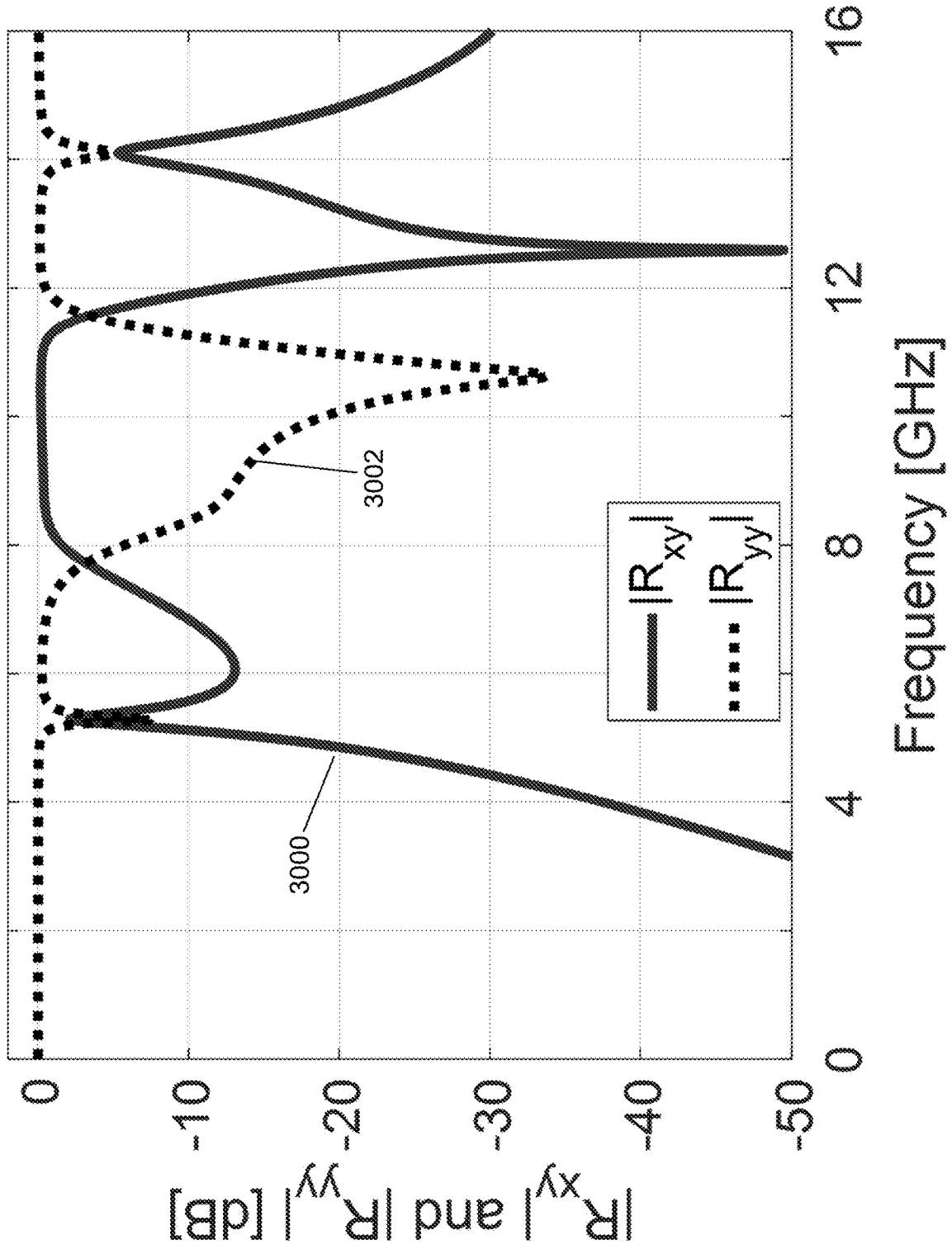


FIG. 30

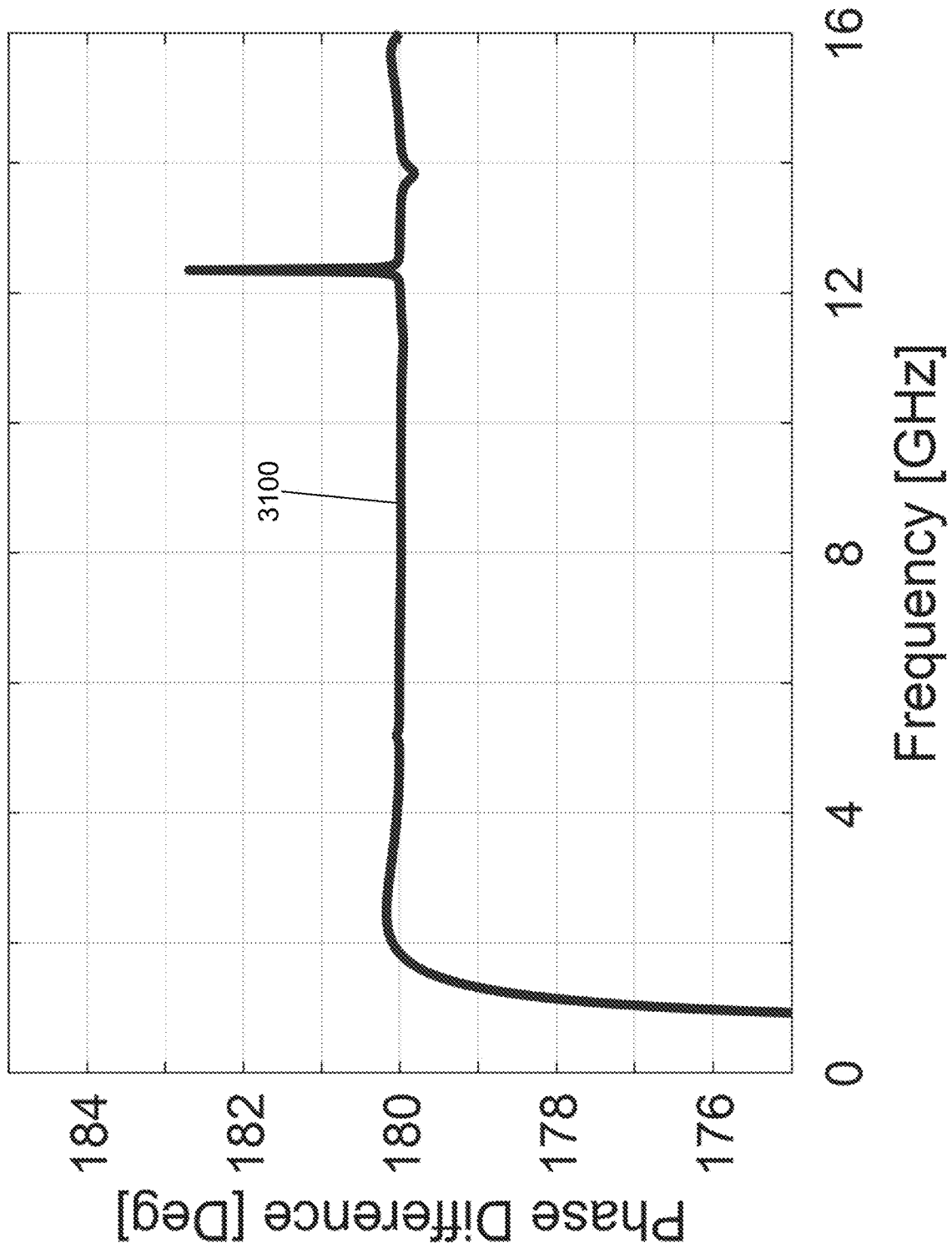


FIG. 31

POLARIZATION ROTATING PHASED ARRAY ELEMENT

REFERENCE TO GOVERNMENT RIGHTS

This invention was made with government support under N00014-16-1-2308 awarded by the US Navy/ONR. The government has certain rights in the invention.

BACKGROUND

A phased array antenna is an array of antennas in which a relative phase of signals feeding each antenna is varied such that an effective radiation pattern of the array is reinforced in a desired direction and suppressed in undesired directions to provide electronic steering of a beam. To convert a reflector array into a beam steerable antenna, a phase shift distribution provided by spatial phase shifting pixels is dynamically changed depending on the direction of the desired output beam in the far field.

Beams are formed by shifting the phase of the signal emitted from each radiating element to provide either constructive or destructive interference to steer the beam. These antenna systems come in different sizes and scales due to several factors such as frequency and power requirements. High-power phased array antenna technology that yields an affordable system is a major problem in the commercial and military wireless industry. The cost of current phased array antenna technology is a major factor that limits application to the most expensive military systems. Additionally, the solid-state technology that lies at the heart of current phased array antenna technology has inherent limitations when it comes to power and heat handling capability due to the generation of a large amount of heat.

One of the desirable features that reflective array antennas offer is beam collimation using planar structures or structures that can conform to the outer surface of a given platform. A typical reflective array antenna consists of an array of terminated, unidirectional radiating elements operating as scatterers. When illuminated with a suitably-designed feed antenna, each element of the array scatters the wave with a different phase shift (or time delay) and amplitude. Collectively, the amplitude and phase (or time delay) responses of the elements are designed to provide beam collimation over the reflective array antenna's aperture. This way, a reflective array antenna can be thought of as an aperture populated with a number of discrete spatial phase shifters or spatial time delay units. Various techniques have been used to design reflective array antennas based on the design of the spatial phase shifters or time delay units that they use.

SUMMARY

In an illustrative embodiment, a phase shifter is provided. The phase shifter includes, but is not limited to, a first dielectric layer, a switch, a conductive layer, a second dielectric layer, a plurality of vias, and a conducting pattern layer. The first dielectric layer includes, but is not limited to, a top, first dielectric surface and a bottom, first dielectric surface. The top, first dielectric surface is on an opposite side of the first dielectric layer relative to the bottom, first dielectric surface. The first dielectric layer is formed of a dielectric material. The switch is mounted to the bottom, first dielectric surface and configured to be switchable between a first conducting position defined by a first throw arm and a second conducting position defined by a second throw arm.

The conductive layer includes, but is not limited to, a top conductive surface and a bottom conductive surface. The top conductive surface is on an opposite side of the first conductive layer relative to the bottom conductive surface. The bottom conductive surface is mounted to the top, first dielectric surface. The conductive layer is formed of a first conductive material. The second dielectric layer includes, but is not limited to, a top, second dielectric surface and a bottom, second dielectric surface. The top, second dielectric surface is on an opposite side of the second dielectric layer relative to the bottom, second dielectric surface. The bottom, second dielectric surface is mounted to the top conductive surface. The second dielectric layer is formed of a second dielectric material. Each via of the plurality of vias is formed of a second conductive material that extends through the first dielectric layer, through a third dielectric material formed in and through the conductive layer, and through the second dielectric layer. Each via of the plurality of vias is connected to the first throw arm or to the second throw arm of the switch. The conducting pattern layer includes, but is not limited to, a plurality of conductors. The plurality of conductors is mounted to the top, second dielectric surface. The conducting pattern layer is formed of a third conductive material. Each conductor of the plurality of conductors is mounted to a distinct via of the plurality of vias. The first conductive material is configured to reflect an electromagnetic wave incident on the conducting pattern layer and on the second dielectric layer. When the incident electromagnetic wave is reflected, an electric polarization of the reflected electromagnetic wave is rotated by 90 degrees compared to an electric polarization of the incident electromagnetic wave when the switch is positioned in the first conducting position and the electric polarization of the reflected electromagnetic wave is rotated by -90 degrees compared to the electric polarization of the incident electromagnetic wave when the switch is positioned in the second conducting position.

In another illustrative embodiment, a phased array antenna is provided. The phased array antenna includes, but is not limited to, a feed antenna and a plurality of phase shift elements distributed linearly in a direction. The feed antenna is configured to radiate an electromagnetic wave. Each spatial phase shift element of the plurality of spatial phase shift elements includes, but is not limited to, a first dielectric layer, a switch, a conductive layer, a second dielectric layer, a plurality of vias, and a conducting pattern layer. The first dielectric layer includes, but is not limited to, a top, first dielectric surface and a bottom, first dielectric surface. The top, first dielectric surface is on an opposite side of the first dielectric layer relative to the bottom, first dielectric surface. The first dielectric layer is formed of a dielectric material. The switch is mounted to the bottom, first dielectric surface and configured to be switchable between a first conducting position defined by a first throw arm and a second conducting position defined by a second throw arm. The conductive layer includes, but is not limited to, a top conductive surface and a bottom conductive surface. The top conductive surface is on an opposite side of the first conductive layer relative to the bottom conductive surface. The bottom conductive surface is mounted to the top, first dielectric surface. The conductive layer is formed of a first conductive material. The second dielectric layer includes, but is not limited to, a top, second dielectric surface and a bottom, second dielectric surface. The top, second dielectric surface is on an opposite side of the second dielectric layer relative to the bottom, second dielectric surface. The bottom, second dielectric surface is mounted to the top conductive surface. The second

dielectric layer is formed of a second dielectric material. Each via of the plurality of vias is formed of a second conductive material that extends through the first dielectric layer, through a third dielectric material formed in and through the conductive layer, and through the second dielectric layer. Each via of the plurality of vias is connected to the first throw arm or to the second throw arm of the switch. The conducting pattern layer includes, but is not limited to, a plurality of conductors. The plurality of conductors is mounted to the top, second dielectric surface. The conducting pattern layer is formed of a third conductive material. The first conductive material is configured to reflect the radiated electromagnetic wave incident on the conducting pattern layer and on the second dielectric layer. When the incident electromagnetic wave is reflected, an electric polarization of the reflected electromagnetic wave is rotated by 90 degrees compared to an electric polarization of the incident electromagnetic wave when the switch is positioned in the first conducting position and the electric polarization of the reflected electromagnetic wave is rotated by -90 degrees compared to the electric polarization of the incident electromagnetic wave when the switch is positioned in the second conducting position.

Other principal features of the disclosed subject matter will become apparent to those skilled in the art upon review of the following drawings, the detailed description, and the appended claims.

BRIEF DESCRIPTION OF THE DRAWINGS

Illustrative embodiments of the disclosed subject matter will hereafter be described referring to the accompanying drawings, wherein like numerals denote like elements.

FIG. 1 depicts a perspective side view of a phase shifting element in accordance with an illustrative embodiment.

FIG. 2 depicts a top view of the phase shifting element of FIG. 1 in accordance with an illustrative embodiment.

FIG. 3 depicts an exploded, perspective side view of the phase shifting element of FIG. 1 in accordance with an illustrative embodiment.

FIG. 4 depicts a bottom view of the phase shifting element of FIG. 1 in accordance with an illustrative embodiment.

FIG. 5A depicts a transparent perspective side view of the phase shifting element of FIG. 1 with dielectric material removed and with electric field and current flow directions shown based on a first switch position in accordance with an illustrative embodiment.

FIG. 5B depicts a second transparent perspective side view of the phase shifting element of FIG. 1 with the dielectric material removed and with the electric field and current flow directions shown based on a second switch position in accordance with an illustrative embodiment.

FIG. 6 depicts a transparent perspective side view of a second phase shifting element similar to that shown in FIG. 1 with an additional dielectric material layer and shown with the second switch position in accordance with an illustrative embodiment.

FIG. 7 depicts a side view of a transceiver system that includes the phase shifting element of FIG. 1, the second phase shifting element of FIG. 6, a third phase shifting element of FIG. 24, or a fourth phase shifting element of FIG. 29 in accordance with illustrative embodiments.

FIG. 8 depicts a perspective view of the transceiver system of FIG. 7 in accordance with an illustrative embodiment.

FIG. 9 depicts a projection of a normalized magnitude of the fields generated by a feed antenna of the transceiver

system of FIG. 7 on an aperture of a reflective array antenna in accordance with an illustrative embodiment.

FIG. 10 depicts a projection of an absolute value of a phase of the fields generated by the feed antenna of the transceiver system of FIG. 7 on the aperture of the reflective array antenna in the phase range from -180° to 180° in accordance with an illustrative embodiment.

FIG. 11 depicts a pattern of a distribution of the switch position of the phase shifting elements of FIG. 1, 6, 24, or 29 on the aperture of the reflective array antenna in accordance with an illustrative embodiment, where "bit 0" indicates the first switch position, and "bit 1" indicates the second switch position.

FIG. 12 depicts incident and reflective electric and magnetic field planes generated by the feed antenna and the reflective array antenna of the transceiver system of FIG. 7 in accordance with an illustrative embodiment.

FIG. 13 depicts an X-Y reflection coefficient and a Y-Y reflection coefficient as a function of frequency of the second phase shifting element of FIG. 6 in accordance with an illustrative embodiment.

FIG. 14 depicts a phase difference as a function of frequency between the second phase shifting element of FIG. 6 in the first switch position and in the second switch position in accordance with an illustrative embodiment.

FIG. 15 depicts a measured and a simulated co-polarization and cross-polarization gain as a function of angle generated by the reflective array antenna of the transceiver system of FIG. 7 with the second phase shifting element of FIG. 6 populating the reflective array with the switch positions as shown in FIG. 11 in accordance with an illustrative embodiment.

FIG. 16 depicts a measured realized gain and directivity as a function of frequency generated by the feed antenna of the transceiver system of FIG. 7 in accordance with an illustrative embodiment.

FIG. 17 depicts a measured realized gain and directivity as a function of frequency generated by the reflective array antenna of the transceiver system of FIG. 7 with the second phase shifting element of FIG. 6 populating the reflective array antenna with the switch positions as shown in FIG. 11 in accordance with an illustrative embodiment.

FIG. 18 depicts a measured total efficiency as a function of frequency generated by the reflective array antenna of the transceiver system of FIG. 7 with the second phase shifting element of FIG. 6 populating the reflective array antenna with the switch positions as shown in FIG. 11 in accordance with an illustrative embodiment.

FIG. 19A depicts a measured co-polarization and cross-polarization gain of the reflective array antenna of the transceiver system of FIG. 7 in the E-plane at 8 Gigahertz (GHz) as a function of angle with the second phase shifting element of FIG. 6 populating the reflective array antenna with the switch positions as shown in FIG. 11 in accordance with an illustrative embodiment.

FIG. 19B depicts a measured co-polarization and cross-polarization gain of the reflective array antenna of the transceiver system of FIG. 7 in the H-plane at 8 GHz as a function of angle with the second phase shifting element of FIG. 6 populating the reflective array antenna with the switch positions as shown in FIG. 11 in accordance with an illustrative embodiment.

FIG. 20A depicts a measured co-polarization and cross-polarization gain of the reflective array antenna of the transceiver system of FIG. 7 in the E-plane at 9 GHz as a function of angle with the second phase shifting element of

FIG. 6 populating the reflective array antenna with the switch positions as shown in FIG. 11 in accordance with an illustrative embodiment.

FIG. 20B depicts a measured co-polarization and cross-polarization gain of the reflective array antenna of the transceiver system of FIG. 7 in the H-plane at 9 GHz as a function of angle with the second phase shifting element of FIG. 6 populating the reflective array antenna with the switch positions as shown in FIG. 11 in accordance with an illustrative embodiment.

FIG. 21A depicts a measured co-polarization and cross-polarization gain of the reflective array antenna of the transceiver system of FIG. 7 in the E-plane at 10 GHz as a function of angle with the second phase shifting element of FIG. 6 populating the reflective array antenna with the switch positions as shown in FIG. 11 in accordance with an illustrative embodiment.

FIG. 21B depicts a measured co-polarization and cross-polarization gain of the reflective array antenna of the transceiver system of FIG. 7 in the H-plane at 10 GHz as a function of angle with the second phase shifting element of FIG. 6 populating the reflective array antenna with the switch positions as shown in FIG. 11 in accordance with an illustrative embodiment.

FIG. 22A depicts a measured co-polarization and cross-polarization gain of the reflective array antenna of the transceiver system of FIG. 7 in the E-plane at 11 GHz as a function of angle with the second phase shifting element of FIG. 6 populating the reflective array antenna with the switch positions as shown in FIG. 11 in accordance with an illustrative embodiment.

FIG. 22B depicts a measured co-polarization and cross-polarization gain of the reflective array antenna of the transceiver system of FIG. 7 in the H-plane at 11 GHz as a function of angle with the second phase shifting element of FIG. 6 populating the reflective array antenna with the switch positions as shown in FIG. 11 in accordance with an illustrative embodiment.

FIG. 23A depicts a measured co-polarization and cross-polarization gain of the reflective array antenna of the transceiver system of FIG. 7 in the E-plane at 12 GHz as a function of angle with the second phase shifting element of FIG. 6 populating the reflective array antenna with the switch positions as shown in FIG. 11 in accordance with an illustrative embodiment.

FIG. 23B depicts a measured co-polarization and cross-polarization gain of the reflective array antenna of the transceiver system of FIG. 7 in the H-plane at 12 GHz as a function of angle with the second phase shifting element of FIG. 6 populating the reflective array antenna with the switch positions as shown in FIG. 11 in accordance with an illustrative embodiment.

FIG. 24 depicts a perspective side view of the third phase shifting element in accordance with an illustrative embodiment.

FIG. 25 depicts a top view of the third phase shifting element of FIG. 24 in accordance with an illustrative embodiment.

FIG. 26 depicts an exploded, perspective side view of the third phase shifting element of FIG. 24 in accordance with an illustrative embodiment.

FIG. 27 depicts a bottom view of the third phase shifting element of FIG. 24 in accordance with an illustrative embodiment.

FIG. 28A depicts a transparent perspective side view of the third phase shifting element of FIG. 24 with dielectric material removed and with electric field and current flow

directions shown based on a first switch position in accordance with an illustrative embodiment.

FIG. 28B depicts a second transparent perspective side view of the third phase shifting element of FIG. 24 with the dielectric material removed and with the electric field and current flow directions shown based on a second switch position in accordance with an illustrative embodiment.

FIG. 29 depicts a perspective side view of the fourth phase shifting element similar to that shown in FIG. 24 with an additional dielectric material layer in accordance with an illustrative embodiment.

FIG. 30 depicts an X-Y reflection coefficient and a Y-Y reflection coefficient as a function of frequency of the fourth phase shifting element of FIG. 29 in accordance with an illustrative embodiment.

FIG. 31 depicts a phase difference as a function of frequency between the fourth phase shifting element of FIG. 29 in the first switch position and in the second switch position in accordance with an illustrative embodiment.

DETAILED DESCRIPTION

With reference to FIG. 1, a perspective side view of a phase shifting element 100 is shown in accordance with an illustrative embodiment. With reference to FIG. 2, a top view of phase shifting element 100 is shown in accordance with an illustrative embodiment. With reference to FIG. 3, an exploded, perspective side view of phase shifting element 100 is shown in accordance with an illustrative embodiment. With reference to FIG. 4, a bottom view of phase shifting element 100 is shown in accordance with an illustrative embodiment. With reference to FIG. 5A, a transparent perspective side view of phase shifting element 100 is shown with dielectric material removed and with electric field and current flow directions shown based on a first switch position in accordance with an illustrative embodiment. With reference to FIG. 5B, a second transparent perspective side view of phase shifting element 100 is shown with the dielectric material removed and with the electric field and current flow directions shown based on a second switch position in accordance with an illustrative embodiment. The separation between layers illustrated in FIGS. 3, 5A, and 5B are exaggerated to more clearly show the arrangement of the components of phase shifting element 100.

Phase shifting element 100 may include a first dielectric layer 102, a conducting layer 104, a second dielectric layer 106, and a conducting pattern layer 107. Phase shifting element 100 provides a polarization rotating surface that can be used as a spatial phase shifter of a single-layer, wideband reflective array antenna. Phase shifting element 100 rotates a polarization of a reflected wave by 90° compared to that of an incident wave. Phase shifting element 100 can be switched between a first configuration and a second configuration that is a geometric mirror image of the first configuration. As such, phase shifting element 100 can be used as a one-bit spatial phase shifter that provides either -90° or +90° polarization rotation compared to that of the incident wave. The two reflected fields have a phase difference of 180° degrees between them. Therefore, if one is taken as a reference, the other one has a phase shift of 180° with respect to the first one. Because phase shifting using phase shifting element 100 is achieved through geometric means, phase shifting element 100 can provide either 0° or 180° phase shift over extremely broad bandwidths.

First dielectric layer 102 is formed of one or more dielectric materials that may include foamed polyethylene,

solid polyethylene, polyethylene foam, polytetrafluoroethylene, air, air space polyethylene, vacuum, etc. Illustrative dielectric materials include RO4003C laminate and RO3006 laminate sold by Rogers Corporation headquartered in Chandler, Ariz., USA.

Second dielectric layer **106** is also formed of one or more dielectric materials. First dielectric layer **102** and second dielectric layer **106** may be formed of the same or different dielectric materials and the same or a different number of layers of dielectric material.

Conducting layer **104** may be formed of a sheet of conductive material such as copper plated steel, silver plated steel, silver plated copper, silver plated copper clad steel, copper, copper clad aluminum, steel, etc. Conducting pattern layer **107** also may be formed of a conductive material such as copper plated steel, silver plated steel, silver plated copper, silver plated copper clad steel, copper, copper clad aluminum, steel, etc. Conducting layer **104** and conducting pattern layer **107** may be formed of the same or a different conductive material. Conducting layer **104** is a conducting surface with high conductivity that reflects received electromagnetic waves. Conducting layer **104** is connected to a fixed potential that may be, but is not necessarily, a ground potential. Conducting layer **104** may be generally flat or formed of ridges or bumps. For illustration, conducting layer **104** may be formed of a flexible membrane coated with a conductor.

Conducting layer **104** is mounted between first dielectric layer **102** and second dielectric layer **106** such that a top surface **310** of first dielectric layer **102** is mounted to a bottom surface of conducting layer **104**, and second dielectric layer **106** is mounted to a top surface **312** of conducting layer **104**. Each of first dielectric layer **102**, conducting layer **104**, and second dielectric layer **106** has a generally square top and bottom surface shape in an x-y plane and a thickness in a vertical direction denoted by a z-axis, where an x-axis is perpendicular to a y-axis, and both the x-axis and the y-axis are perpendicular to the z-axis to form a right-handed coordinate reference frame denoted x-y-z frame **122**. First dielectric layer **102**, conducting layer **104**, and second dielectric layer **106** have a length **120** parallel to the x-axis, and a width **121** parallel to the y-axis. In the illustrative embodiment, length **120** is equal to width **121**.

Second dielectric layer **106** has a back wall **108**, a right-side wall **110**, a front wall **112**, a left-side wall **114**, a top surface **115**, and a bottom surface (not shown). The bottom surface of second dielectric layer **106** is mounted to top surface **312** of conducting layer **104**.

The top and bottom surfaces of each of first dielectric layer **102**, conducting layer **104**, and second dielectric layer **106** are generally flat. First dielectric layer **102** has a first thickness **116** parallel to the z-axis. Conducting layer **104** has a second thickness **117** parallel to the z-axis. Second dielectric layer **106** has a third thickness **118** parallel to the z-axis.

Conducting pattern layer **107** is formed on top surface **115** of second dielectric layer **106** opposite conducting layer **104**. Conducting pattern layer **107** includes a first corner conductor **124a**, a second corner conductor **124b**, a third corner conductor **124c**, and a fourth corner conductor **124d**. In the illustrative embodiment, first corner conductor **124a**, second corner conductor **124b**, third corner conductor **124c**, and fourth corner conductor **124d** each form an open arrow shape pointed at 135°, 45°, 315°, and 225°, respectively, in the x-y plane and relative to the +x-direction. Thus, a tip of each open arrow shape is pointed in a direction that is rotated 90° relative to each adjacent tip.

First corner conductor **124a**, second corner conductor **124b**, third corner conductor **124c**, and fourth corner conductor **124d** are symmetrically distributed relative to each corner of top surface **115** of second dielectric layer **106**. First corner conductor **124a** and second corner conductor **124b** form a mirror image of third corner conductor **124c** and fourth corner conductor **124d** relative to an x-z center plane through a center **134** of top surface **115** of second dielectric layer **106**. The x-z center plane is parallel to the x-z plane defined by x-y-z frame **122**. First corner conductor **124a** and fourth corner conductor **124d** form a mirror image of second corner conductor **124b** and third corner conductor **124c** relative to a y-z center plane through center **134** of top surface **115** of second dielectric layer **106**. The y-z center plane is parallel to the y-z plane defined by x-y-z frame **122**.

First corner conductor **124a** is positioned in an upper left quadrant of top surface **115** of second dielectric layer **106**. First corner conductor **124a** includes a first switch connector **126a**, a first connecting arm **128a**, a first x-arm **130a**, and a first y-arm **132a**. First x-arm **130a** and first y-arm **132a** are perpendicular to each other, and first connecting arm **128a** bisects the corner in which first x-arm **130a** and first y-arm **132a** join each other. As a result, first connecting arm **128a** is aligned with and extends from the tip formed at the intersection of first x-arm **130a** and first y-arm **132a**. First switch connector **126a**, first connecting arm **128a**, first x-arm **130a**, and first y-arm **132a** are used to describe a shape of first corner conductor **124a** and typically are not distinct elements but form a single conductive structure.

First switch connector **126a** connects first corner conductor **124a** to a first vertical interconnect access (via) **302a**. First connecting arm **128a** connects first x-arm **130a** and first y-arm **132a** to first switch connector **126a**. First connecting arm **128a** extends parallel to a diagonal between center **134** and an upper left corner **136**. First x-arm **130a** extends from upper left corner **136** towards an upper right corner **138** parallel to the x-axis. First y-arm **132a** extends from upper left corner **136** towards a lower left corner **142** parallel to the y-axis.

First x-arm **130a** is a first distance **200** from back wall **108**. First y-arm **132a** is first distance **200** from left-side wall **114**. First x-arm **130a** has a corner arm length **202** and a corner arm width **204**. First y-arm **132a** has corner arm length **202** and corner arm width **204**. First connecting arm **128a** has an arm length **208** and an arm width **206**. For simplicity of description, first x-arm **130a**, first y-arm **132a**, and first connecting arm **128a** have been described to overlap near an upper left corner **136** though again first switch connector **126a**, first connecting arm **128a**, first x-arm **130a**, and first y-arm **132a** typically are not distinct elements, but form a single conductive structure. Similarly, for simplicity of description, first switch connector **126a** overlaps an end of first connecting arm **128a**. First switch connector **126a** is illustrated as having a square shape though it may have other shapes including circular, oval, triangular, etc.

First via **302a** forms an electrical connection between a first throw arm **306** of a switch **304** through first dielectric layer **102**, conducting layer **104**, and second dielectric layer **106** to form an electronic circuit. First via **302a** is formed of a conductive material. A first dielectric patch **300a** is formed through conducting layer **104** of a dielectric material. First via **302a** extends generally parallel to the z-axis through first dielectric patch **300a**.

Second corner conductor **124b** is positioned in an upper right quadrant of top surface **115** of second dielectric layer **106**. Second corner conductor **124b** includes a second

switch connector **126b**, a second connecting arm **128b**, a second x-arm **130b**, and a second y-arm **132b**. Second x-arm **130b** and second y-arm **132b** are perpendicular to each other, and second connecting arm **128b** bisects the corner in which second x-arm **130b** and second y-arm **132b** join each other. As a result, second connecting arm **128b** is aligned with and extends from the tip formed at the intersection of second x-arm **130b** and second y-arm **132b**. Second switch connector **126b**, second connecting arm **128b**, second x-arm **130b**, and second y-arm **132b** are used to describe a shape of second corner conductor **124b** and typically are not distinct elements but form a single conductive structure.

Second switch connector **126b** connects second corner conductor **124b** to a second via **302b**. Second connecting arm **128b** connects second x-arm **130b** and second y-arm **132b** to second switch connector **126b**. Second connecting arm **128b** extends parallel to a diagonal between center **134** and upper right corner **138**. Second x-arm **130b** extends from upper right corner **138** towards upper left corner **136** parallel to the x-axis. Second y-arm **132b** extends from upper right corner **138** towards a lower right corner **140** parallel to the y-axis.

Second x-arm **130b** is first distance **200** from back wall **108**. Second y-arm **132b** is first distance **200** from right-side wall **110**. Second x-arm **130b** has corner arm length **202** and corner arm width **204**. Second y-arm **132b** has corner arm length **202** and corner arm width **204**. Second connecting arm **128b** has arm length **208** and arm width **206**. For simplicity of description, second x-arm **130b**, second y-arm **132b**, and second connecting arm **128b** have been described to overlap near upper right corner **138** though again second switch connector **126b**, second connecting arm **128b**, second x-arm **130b**, and second y-arm **132b** typically are not distinct elements, but form a single conductive structure. Similarly, for simplicity of description, second switch connector **126b** overlaps an end of second connecting arm **128b**. Second switch connector **126b** is illustrated as having a square shape though it may have other shapes including circular, oval, triangular, etc.

Second via **302b** forms an electrical connection between a second throw arm **308** of switch **304** through first dielectric layer **102**, conducting layer **104**, and second dielectric layer **106** to form an electronic circuit. Second via **302b** is formed of a conductive material. A second dielectric patch **300b** is formed through conducting layer **104** of a dielectric material. Second via **302b** extends generally parallel to the z-axis through second dielectric patch **300b**.

Third corner conductor **124c** is positioned in a lower right quadrant of top surface **115** of second dielectric layer **106**. Third corner conductor **124c** includes a third switch connector **126c**, a third connecting arm **128c**, a third x-arm **130c**, and a third y-arm **132c**. Third x-arm **130c** and third y-arm **132c** are perpendicular to each other, and third connecting arm **128c** bisects the corner in which third x-arm **130c** and third y-arm **132c** join each other. As a result, third connecting arm **128c** is aligned with and extends from the tip formed at the intersection of third x-arm **130c** and third y-arm **132c**. Third connecting arm **128c** and first connecting arm **128a** are parallel to each other. Third switch connector **126c**, third connecting arm **128c**, third x-arm **130c**, and third y-arm **132c** are used to describe a shape of third corner conductor **124c** and typically are not distinct elements but form a single conductive structure.

Third switch connector **126c** connects third corner conductor **124c** to a third via **302c**. Third connecting arm **128c** connects third x-arm **130c** and third y-arm **132c** to third switch connector **126c**. Third connecting arm **128c** extends

parallel to a diagonal between center **134** and lower right corner **140**. Third x-arm **130c** extends from lower right corner **140** towards lower left corner **142** parallel to the x-axis. Third y-arm **132c** extends from lower right corner **140** towards upper right corner **138** parallel to the y-axis.

Third x-arm **130c** is first distance **200** from front wall **112**. Third y-arm **132c** is first distance **200** from right-side wall **110**. Third x-arm **130c** has corner arm length **202** and corner arm width **204**. Third y-arm **132c** has corner arm length **202** and corner arm width **204**. Third connecting arm **128c** has arm length **208** and arm width **206**. For simplicity of description, third x-arm **130c**, third y-arm **132c**, and third connecting arm **128c** have been described to overlap near lower right corner **140** though again third switch connector **126c**, third connecting arm **128c**, third x-arm **130c**, and third y-arm **132c** typically are not distinct elements, but form a single conductive structure. Similarly, for simplicity of description, third switch connector **126c** overlaps an end of third connecting arm **128c**. Third switch connector **126c** is illustrated as having a square shape though it may have other shapes including circular, oval, triangular, etc.

Third via **302c** forms an electrical connection between first throw arm **306** of switch **304** through first dielectric layer **102**, conducting layer **104**, and second dielectric layer **106** to form an electronic circuit. Third via **302c** is formed of a conductive material. A third dielectric patch **300c** is formed through conducting layer **104** of a dielectric material. Third via **302c** extends generally parallel to the z-axis through third dielectric patch **300c**.

Fourth corner conductor **124d** is positioned in a lower left quadrant of top surface **115** of second dielectric layer **106**. Fourth corner conductor **124d** includes a fourth switch connector **126d**, a fourth connecting arm **128d**, a fourth x-arm **130d**, and a fourth y-arm **132d**. Fourth x-arm **130d** and fourth y-arm **132d** are perpendicular to each other, and fourth connecting arm **128d** bisects the corner in which fourth x-arm **130d** and fourth y-arm **132d** join each other. As a result, fourth connecting arm **128d** is aligned with and extends from the tip formed at the intersection of fourth x-arm **130d** and fourth y-arm **132d**. Fourth connecting arm **128d** and second connecting arm **128b** are parallel to each other. Fourth switch connector **126d**, fourth connecting arm **128d**, fourth x-arm **130d**, and fourth y-arm **132d** are used to describe a shape of fourth corner conductor **124d** and typically are not distinct elements but form a single conductive structure.

Fourth switch connector **126d** connects fourth corner conductor **124d** to a fourth via **302d**. Fourth connecting arm **128d** connects fourth x-arm **130d** and fourth y-arm **132d** to fourth switch connector **126d**. Fourth connecting arm **128d** extends parallel to a diagonal between center **134** and lower left corner **142**. Fourth x-arm **130d** extends from lower left corner **142** towards lower right corner **140** parallel to the x-axis. Fourth y-arm **132c** extends from lower left corner **142** towards upper left corner **136** parallel to the y-axis.

Fourth x-arm **130d** is first distance **200** from front wall **112**. Fourth y-arm **132d** is first distance **200** from left-side wall **114**. Fourth x-arm **130d** has corner arm length **202** and corner arm width **204**. Fourth y-arm **132d** has corner arm length **202** and corner arm width **204**. Fourth connecting arm **128d** has arm length **208** and arm width **206**. For simplicity of description, fourth x-arm **130d**, fourth y-arm **132d**, and fourth connecting arm **128d** have been described to overlap near lower left corner **142** though again fourth switch connector **126d**, fourth connecting arm **128d**, fourth x-arm **130d**, and fourth y-arm **132d** typically are not distinct elements, but form a single conductive structure. Similarly,

for simplicity of description, fourth switch connector **126d** overlaps an end of fourth connecting arm **128d**. Fourth switch connector **126d** is illustrated as having a square shape though it may have other shapes including circular, oval, triangular, etc.

Fourth via **302d** forms an electrical connection between second throw arm **308** of switch **304** through first dielectric layer **102**, conducting layer **104**, and second dielectric layer **106** to form an electronic circuit. Fourth via **302d** is formed of a conductive material. A fourth dielectric patch **300d** is formed through conducting layer **104** of a dielectric material. Fourth via **302d** extends generally parallel to the z-axis through fourth dielectric patch **300d**.

Inclusion of first x-arms **130a**, **130b**, **130c**, **130d** perpendicular to first y-arms **132a**, **132b**, **132c**, **132d**, respectively, allows phase shifting element **100** to support polarizations parallel to the x-axis as well as the y-axis.

Switch **304** is a double pole, double throw (DPDT) switch. In a first position, first throw arm **306** of switch **304** is closed to electrically connect first via **302a** and third via **302c**. In a second position, second throw arm **308** of switch **304** is closed to electrically connect second via **302b** and fourth via **302d**. Switch **304** is mounted to bottom surface **400** of first dielectric layer **102**. When switch **304** is in the first position, phase shifting element **100** may be designated as in a bit zero, "bit 0", configuration. When switch **304** is in the second position, phase shifting element **100** may be designated as in a bit one, "bit 1", configuration. Of course, the configurations can be reversed. Switch **304** may be a mechanical switch, a microelectromechanical system (MEMS) switch, a commercially available DPDT switch, a plurality of PIN diodes, etc.

A combined electrical path length of first connecting arm **128a** and first via **302a** is approximately $\lambda_0/4$ (a quarter of the wavelength) and includes arm length **208** that defines a length of first connecting arm **128a** and third thickness **118**, third thickness **117**, and third thickness **116** that define a length of first via **302a**. Similarly, a combined electrical path length of second connecting arm **128b** and second via **302b** is approximately $\lambda_0/4$. Similarly, a combined electrical path length of third connecting arm **128c** and third via **302c** is approximately $\lambda_0/4$. Similarly, a combined electrical path length of fourth connecting arm **128d** and fourth via **302d** is approximately $\lambda_0/4$. λ_0 is the wavelength in free space at the frequency of operation.

An electrical path length of each of first throw arm **306** and of second throw arm **308** of switch **304** can be set in the range from $\lambda_0/100$ to $\lambda_0/5$ (e.g. based on a range of physical dimensions of several commercial electronic switches and PIN diodes). The electrical path length for the currents of switch **304** is included in a total electrical path length for each connected pair of arms (e.g., first connecting arm **128a** and first via **302a** connected to third connecting arm **128c** and third via **302c**) when connected by first throw arm **306** or second throw arm **308** of switch **304**. The total electrical path length of each connected pair of arms is approximately half a wavelength.

With reference to FIG. 5A, the first position that defines the bit zero configuration is shown in accordance with an illustrative embodiment. In the first position, first throw arm **306** of switch **304** is closed to electrically connect first via **302a** and third via **302c** thereby electrically connecting first corner conductor **124a** to third corner conductor **124c**. First connecting arm **128a**, first throw arm **306**, and third connecting arm **128c** are parallel to each other and form an angle of 135° relative to the x-axis. When first connecting arm **128a** and third connecting arm **128c** are electrically

connected via first throw arm **306** of switch **304**, a total electrical length of an extended electrical pathway, which includes first x-arm **130a**, first y-arm **132a**, first connecting arm **128a**, first switch connector **126a**, first via **302a**, first throw arm **306**, third via **302c**, third switch connector **126c**, third connecting arm **128c**, third x-arm **130c**, and third y-arm **132c**, is approximately half a wavelength. This results in very small currents flowing on first connecting arm **128a** and third connecting arm **128c** and large currents flowing on first throw arm **306** and first via **302a** and third via **302c**, thus deactivating the polarization rotating effect of this pair of arms.

On the other hand, second connecting arm **128b** and fourth connecting arm **128d** are electrically isolated, and the electrical length of each electrical pathway of second corner conductor **124b** (second x-arm **130b**, second y-arm **132b**, second connecting arm **128b**, second switch connector **126b**, second via **302b**) and of fourth corner conductor **124d** (fourth x-arm **130d**, fourth y-arm **132d**, fourth connecting arm **128d**, fourth switch connector **126d**, fourth via **302d**) is approximately a quarter wavelength, which results in large currents flowing on second connecting arm **128b** and fourth connecting arm **128d** as indicated in FIG. 5A. For an incident wave with an incident electric field E_i **500** in the $-x$ direction parallel to the x-axis, a periodic structure consisting of phase shifting elements **100** in the bit zero configuration rotates the polarization of the reflected wave by 90° resulting in a reflected wave with a reflected electric field E_r **508** in the $-y$ direction parallel to the y-axis.

A first incident wave vector k_i **502** points in a direction of incident wave propagation. A first reflected wave vector k_r **510** points in a direction of reflected wave propagation. The magnitude of first incident wave vector k_i **502** and of first reflected wave vector k_r **510** are $2\pi/\lambda_0$.

With reference to FIG. 5B, the second position that defines the bit one configuration is shown in accordance with an illustrative embodiment. In the second position, second throw arm **308** of switch **304** is closed to electrically connect second via **302b** and fourth via **302d** thereby electrically connecting second corner conductor **124b** to fourth corner conductor **124d**. Second connecting arm **128b**, second throw arm **308**, and fourth connecting arm **128d** are parallel to each other and form an angle of 45° relative to the x-axis. When second connecting arm **128b** and fourth connecting arm **128d** are electrically connected via second throw arm **308** of switch **304**, a total electrical length of an extended electrical pathway, which includes second x-arm **130b**, second y-arm **132b**, second connecting arm **128b**, second switch connector **126b**, second via **302b**, second throw arm **308**, fourth via **302d**, fourth switch connector **126d**, fourth connecting arm **128d**, fourth x-arm **130d**, and fourth y-arm **132d**, is approximately half a wavelength. This results in very small currents flowing on second connecting arm **128b** and fourth connecting arm **128d** and large currents flowing on second throw arm **308** and second via **302b** and fourth via **302d** thus deactivating the polarization rotating effect of this pair of arms.

On the other hand, first connecting arm **128a** and second connecting arm **128c** are electrically isolated, and the electrical length of each electrical pathway of first corner conductor **124a** (first x-arm **130a**, first y-arm **132a**, first connecting arm **128a**, first switch connector **126a**, first via **302a**) and of third corner conductor **124c** (third x-arm **130c**, third y-arm **132c**, third connecting arm **128c**, third switch connector **126c**, third via **302c**) is approximately a quarter wavelength, which results in large currents flowing on first connecting arm **128a** and second connecting arm **128c** as

indicated in FIG. 5B. For the incident wave with the incident electric field E_i 500 in the $-x$ direction parallel to the x-axis, a periodic structure consisting of phase shifting elements 100 in the bit one configuration rotates the polarization of the reflected wave by -90° resulting in a reflected wave with a reflected electric field E_r 516 in the $+y$ direction parallel to the y-axis.

As a result, depending on whether phase shifting element 100 is in the bit zero configuration or in the bit one configuration based on the position of the throw arms of switch 304, phase shifting element 100 rotates the polarization of the reflected electric field by $+90^\circ$ or by -90° with respect to the polarization of the incident electric field. As a result, the two different modes supported by phase shifting element 100 provides reflected electric field E_r 508 and reflected electric field E_r 516 that are in opposite directions as shown in FIGS. 5A and 5B creating a phase difference of 180° between the reflected waves in these modes.

Dimensions for phase shifting element 100 can be determined based on the following:

$$0 < P \leq \frac{\lambda_0}{2}$$

$$\frac{\lambda_{eff}}{10} \leq l_1 \leq \frac{\lambda_{eff}}{4}; l_1 < \frac{P}{\sqrt{2}}; \lambda_{eff} \approx \frac{\lambda_0}{\sqrt{\frac{1+\epsilon_{r,1}}{2}}}$$

$$\frac{\lambda_{eff}}{10} \leq l_2 \leq \frac{\lambda_{eff}}{4}; l_2 < \frac{P}{2}$$

$$\frac{\lambda_0}{10} \leq h_1 \times \sqrt{\epsilon_{r,1}} + \dots + h_{n-1} \times \sqrt{\epsilon_{r,n-1}} \leq \frac{\lambda_0}{3}$$

$$0 \leq h_m \times \sqrt{\epsilon_{r,m}} < \lambda_0$$

$$0 < w_1 \leq \frac{\lambda_0}{10}$$

$$0 < w_2 \leq \frac{\lambda_0}{10}$$

$$0 < s \leq \frac{\lambda_0}{10}$$

where $\lambda_0=c/f_0$, where c is the speed of light and f_0 is a carrier frequency, where P is length 120 and width 121, l_1 is arm length 208, w_1 is arm width 206, l_2 is corner arm length 202, w_2 is corner arm width 204, s is first distance 200, $\epsilon_{r,1}$ is a relative permittivity of a top layer of second dielectric layer 106, h_1 is third thickness 118 of the top layer of second dielectric layer 106, $\epsilon_{r,n-1}$ is a relative permittivity of a next layer of second dielectric layer 106 when second dielectric layer 106 is formed of a plurality of dielectric layers n , h_{n-1} is a thickness of the next layer of second dielectric layer 106 when second dielectric layer 106 is formed of a plurality of dielectric layers n , $\epsilon_{r,m}$ is a relative permittivity of first dielectric layer 102, h_m is first thickness 116 of first dielectric layer 102. When second dielectric layer 106 is formed of the plurality of dielectric layers n , third thickness 118 is a total thickness of second dielectric layer 106. As an example, for $f_0 \in [1,30]$ GHz, $\lambda_0 \in [30,1]$ centimeters (cm).

Referring to FIG. 6, a transparent perspective side view of a second phase shifting element 600 is shown in accordance with an illustrative embodiment. Second phase shifting element 600 includes first dielectric layer 102, conducting layer 104, a third dielectric layer 106a, and conducting pattern layer 107. Third dielectric layer 106a is similar to second dielectric layer 106 except that it is formed of two

dielectric layers, a top dielectric layer 602 and a sandwiched dielectric layer 604. Conducting pattern layer 107 is formed on top surface 115 of top dielectric layer 602 and has a fourth thickness 606. Sandwiched dielectric layer 604 is mounted between top dielectric layer 602 and conducting layer 104 and has a fifth thickness 608. In the illustrative embodiment of FIG. 6, sandwiched dielectric layer 604 is formed of air. Top dielectric layer 602 and first dielectric layer 102 are formed of RO4003C material with a dielectric constant of 3.4 and a loss tangent of 0.0027. Third thickness 118 is equal to fourth thickness 606 plus fifth thickness 608.

Generally, a thickness of conducting layer 104 and of conducting pattern layer 107 is at least several times that of a skin depth of the conductive material at the operating frequency to make sure the incident wave cannot penetrate through first dielectric layer 102 and a high reflection coefficient is achieved. For a good conductor such as copper, the skin depth is less than 2 micrometers (μm) if the frequency is higher than 1 GHz. Therefore, the thickness of conducting layer 104 and of conducting pattern layer 107, for example, provided in printed circuit board fabrication technology ($>17 \mu\text{m}$), is generally many times larger than the skin depth of copper. As long as this condition is satisfied, the value of the thickness of conducting layer 104 and of conducting pattern layer 107 does not have a significant role in the design of phase shifting element 100 or of second phase shifting element 600.

Second phase shifting element 600 was constructed in two embodiments to correspond with the first position and with the second position of switch 304. For simplicity of construction, each embodiment had a fixed position instead of using switch 304. For example, FIG. 6 shows a first embodiment of second phase shifting element 600 in the second position to form the bit one configuration and to electrically connect second via 302b and fourth via 302d. Though not shown, a second embodiment of second phase shifting element 600 in the first position to form the bit zero configuration and to electrically connect first via 302a and third via 302c was also constructed.

Illustrative dimensions for second phase shifting element 600 are $P=6$ millimeters (mm) for length 120 and width 121, $l_1=2.7$ mm for arm length 208, $w_1=0.25$ mm for arm width 206, $l_2=2.2$ mm for corner arm length 202, $w_2=0.3$ mm for corner arm width 204, $s=0.15$ mm for first distance 200, $\epsilon_{r,1}$ is a relative permittivity of RO4003C material, $h_1=1$ mm for fourth thickness 606, $\epsilon_{r,2}$ is a relative permittivity of air, $h_2=3$ mm for fifth thickness 608 such that third thickness 118 is 4 mm, $\epsilon_{r,m}$ is a relative permittivity of RO4003C material, and $h_m=1$ mm for first thickness 116 of first dielectric layer 102. For illustration, second phase shifting element 600 can be fabricated using printed circuit board technology.

Referring to FIG. 7, a one-dimensional (1-D) side view of a transceiver system 700 is shown in accordance with an illustrative embodiment. Transceiver system 700 may include a feed antenna 702 and a plurality of phase shifting elements. Transceiver system 700 may act as a transmitter or a receiver of analog or digital signals. The plurality of phase shifting elements is arranged to form a reflective array antenna 704. Reflective array antenna 704 may be populated with any of phase shifting element 100, second phase shifting element 600, a third phase shifting element 2400 (shown referring to FIG. 24), or a fourth phase shifting element 2900 (shown referring to FIG. 29).

Feed antenna 702 may have a low-gain. Feed antenna 702 may be a dipole antenna, a monopole antenna, a helical antenna, a microstrip antenna, a patch antenna, a fractal antenna, a feed horn, a slot antenna, an end fire antenna, a

parabolic antenna, etc. Feed antenna 702 is positioned a focal distance 712, f_d , from a front face 705 of the plurality of phase shifting elements. Feed antenna 702 is configured to receive an analog or a digital signal, and in response, to radiate a spherical radio wave 706 toward front face 705 of the plurality of phase shifting elements. For example, front face 705 may include conducting pattern layer 107 of each phase shifting element. Feed antenna 702 also may be configured to receive spherical radio wave 706 from front face 705 of the plurality of phase shifting elements and to generate an analog or a digital signal in response.

The plurality of phase shifting elements may be arranged to form a one-dimensional (1D) or a two-dimensional (2D) array of spatial phase shift elements in any direction. The plurality of phase shifting elements may form variously shaped apertures including circular, rectangular, square, elliptical, etc. The plurality of phase shifting elements can include any number of phase shifting elements.

Referring to FIG. 8, a perspective view of transceiver system 700 is shown with a circular aperture. Feed antenna 702 is illustrated as a feed horn and is positioned at a center of reflective array antenna 704. The plurality of phase shifting elements are arranged to form a circular 2D array of phase shifting elements. The plurality of phase shifting elements has an aperture length 710, D.

Spherical radio wave 706 reaches different portions of front face 705 at different times. The plurality of phase shifting elements can be considered to be a plurality of pixels each of which act as a phase shift unit by providing a selected phase shift within the frequency band of interest. Thus, each phase shifting element of the plurality of phase shifting elements acts as a phase shift circuit selected such that spherical radio wave 706 is re-radiated in the form of a planar wave 708 that is parallel to front face 705, or vice versa. Given aperture length 710 and focal distance 712, the phase shift profile provided for the plurality of phase shifting elements to form planar wave 708 directed to a specific angle can be calculated as understood by a person of skill in the art. Center 134 of each phase shifting element is separated a distance 714 from center 134 of its neighbors in any direction. Distance 714 may be equal to length 120 and width 121.

For example, assuming feed antenna 702 is aligned to emit spherical radio wave 706 at the focal point of the plurality of phase shifting elements, the time it takes for each ray to arrive at front face 705 is determined by a length of each ray trace, i.e., the distance traveled by the electromagnetic wave traveling at the speed of light. A minimum time corresponds to a propagation time of the shortest ray trace, which is the line path from feed antenna 702 to a center of front face 705 for a center positioned feed antenna 702. A maximum time corresponds to a propagation time of the longest ray trace, which is the line path from feed antenna 702 to an edge of front face 705 for the center positioned feed antenna 702. Feed antenna 702 may be positioned at an off-center position with a resulting change in the distribution of ray traces to each phase shifting element. Of course, because the distance varies between feed antenna 702 and each phase shifting element of reflective array antenna 704, a magnitude of the portion of spherical radio wave 706 received by each phase shifting element also varies. For example, referring to FIG. 9, a normalized magnitude of the fields generated by feed antenna 702 projected on front face 705 of reflective array antenna 704 is shown for a square array composed of 50 phase shifting elements in both the x-axis direction and the y-axis direction. Aperture length 710 and width was approximately 30 cm using second phase

shifting element 600. Focal distance 712 was also 30 cm. Referring to FIG. 10, a phase of the fields generated by feed antenna 702 projected on front face 705 of reflective array antenna 704 is shown. To achieve beam collimation and form planar wave 708, each phase shifting element of the plurality of phase shifting elements provides a reverse phase shift profile.

Referring to FIG. 11, a pattern of a distribution of the switch position of the phase shifting elements arranged on reflective array antenna 704 is shown in accordance with an illustrative embodiment, where "bit 0" indicates the first switch position that defines the bit zero configuration and "bit 1" indicates the second switch position that defines the bit one configuration. The pattern was determined such that the first switch position was used for each phase shifting element at a location having a phase angle of the incident electric field between -90° and 90° , and the second switch position was used for each phase shifting element at a location having a phase angle of the incident electric field between 90° and 180° or between -180° and -90° .

Referring to FIG. 12, an incident electric field plane 1200 and an incident magnetic field plane 1202 generated by feed antenna 702 and a reflected electric field plane 1204 and a reflected magnetic field plane 1206 generated by reflective array antenna 704 are shown in accordance with an illustrative embodiment. The relative change in angle between the incident and the reflective planes is 90° .

Referring to FIG. 13, an X-Y reflection coefficient curve 1300 and a Y-Y reflection coefficient curve 1302 show an X-Y reflection coefficient and a Y-Y reflection coefficient, respectively, as a function of frequency that result for second phase shifting element 600 designed using the illustrative dimensions above. Incident electric field plane 1200 was polarized parallel to the y-axis.

Referring to FIG. 14, a phase difference curve 1400 shows a phase difference as a function of frequency between the two embodiments of second phase shifting element 600 in the first switch position and in the second switch position in accordance with an illustrative embodiment. The phase difference is 180° within the intended operating frequency range (7-13 GHz) of second phase shifting element 600. The blip in phase difference curve 1400 that occurs at ~ 4.2 GHz is likely due to a transition between R_{yy} -dominant reflection to R_{xx} -dominant reflection around this frequency as shown in FIG. 13. This frequency is outside of the intended operating frequency range of second phase shifting element 600 (e.g. 7-13 GHz) so it is not a concern.

Referring to FIG. 15, a radiation pattern is shown in accordance with an illustrative embodiment for reflective array antenna 704. Second phase shifting element 600 populated each of the 50 by 50 array of pixel positions on reflective array antenna 704. A first gain curve 1500 shows measured co-polarization levels normalized to their maximum value as a function of angle. A second gain curve 1502 shows measured cross-polarization levels normalized to their maximum value as a function of angle. A third gain curve 1504 shows simulated co-polarization levels normalized to their maximum value as a function of angle. A fourth gain curve 1506 shows simulated cross-polarization as a function of angle. The simulated data was generated using full-wave electromagnetic simulation.

Referring to FIG. 16, a measured realized gain curve 1600 and a measured directivity curve 1602 show a gain and a directivity, respectively, as a function of frequency generated by feed antenna 704 in accordance with an illustrative embodiment.

Referring to FIG. 17, a measured realized gain curve **1700** and a measured directivity curve **1702** show a gain and a directivity, respectively, as a function of frequency generated by reflective array antenna **704** with second phase shifting element **600** populating each pixel position. A 3 decibel (dB) bandwidth existed between approximately 9 and 12.9 GHz.

Referring to FIG. 18, a measured total efficiency curve **1800** shows a total efficiency of reflective array antenna **704** with second phase shifting element **600** populating each pixel position as a function of frequency.

Referring to FIG. 19A, a measured co-polarization gain curve **1900** and a measured cross-polarization gain curve **1902** are shown as a function of angle in the E-plane at $f_0=8$ GHz using reflective array antenna **704** with second phase shifting element **600** populating each pixel position. Referring to FIG. 19B, a measured co-polarization gain curve **1904** and a measured cross-polarization gain curve **1906** are shown as a function of angle in the H-plane at $f_0=8$ GHz using reflective array antenna **704** with second phase shifting element **600** populating each pixel position.

Referring to FIG. 20A, a measured co-polarization gain curve **2000** and a measured cross-polarization gain curve **2002** are shown as a function of angle in the E-plane at $f_0=9$ GHz using reflective array antenna **704** with second phase shifting element **600** populating each pixel position. Referring to FIG. 20B, a measured co-polarization gain curve **2004** and a measured cross-polarization gain curve **2006** are shown as a function of angle in the H-plane at $f_0=9$ GHz using reflective array antenna **704** with second phase shifting element **600** populating each pixel position.

Referring to FIG. 21A, a measured co-polarization gain curve **2100** and a measured cross-polarization gain curve **2102** are shown as a function of angle in the E-plane at $f_0=10$ GHz using reflective array antenna **704** with second phase shifting element **600** populating each pixel position. Referring to FIG. 21B, a measured co-polarization gain curve **2104** and a measured cross-polarization gain curve **2106** are shown as a function of angle in the H-plane at $f_0=10$ GHz using reflective array antenna **704** with second phase shifting element **600** populating each pixel position.

Referring to FIG. 22A, a measured co-polarization gain curve **2200** and a measured cross-polarization gain curve **2202** are shown as a function of angle in the E-plane at $f_0=11$ GHz using reflective array antenna **704** with second phase shifting element **600** populating each pixel position. Referring to FIG. 22B, a measured co-polarization gain curve **2204** and a measured cross-polarization gain curve **2206** are shown as a function of angle in the H-plane at $f_0=11$ GHz using reflective array antenna **704** with second phase shifting element **600** populating each pixel position.

Referring to FIG. 23A, a measured co-polarization gain curve **2300** and a measured cross-polarization gain curve **2302** are shown as a function of angle in the E-plane at $f_0=12$ GHz using reflective array antenna **704** with second phase shifting element **600** populating each pixel position. Referring to FIG. 23B, a measured co-polarization gain curve **2304** and a measured cross-polarization gain curve **2306** are shown as a function of angle in the H-plane at $f_0=12$ GHz using reflective array antenna **704** with second phase shifting element **600** populating each pixel position.

The measured realized gains vary within 0.8 dB over the frequency range of 10-12 GHz with a maximum value of 23.5 dBi (dB relative to an isotropic radiator) at 11.2 GHz. Reflective array antenna **704** provides low side lobe levels and high polarization purity in this frequency range. Specifically, the measured side lobe levels are 15 dB, 13 dB, and

11.5 dB lower than the main lobe levels at 10 GHz, 11 GHz, and 12 GHz, respectively. The measured cross-polarization levels are 14 dB, 13 dB, and 11 dB below the co-polarization levels at 10, 11, and 12 GHz, respectively. The lowest side lobe level and highest polarization purity within this frequency range were achieved at 10 GHz, at which the pattern of the 1-bit phase shifters is optimized.

With reference to FIG. 24, a perspective side view of third phase shifting element **2400** is shown in accordance with an illustrative embodiment. With reference to FIG. 25, a top view of third phase shifting element **2400** is shown in accordance with an illustrative embodiment. With reference to FIG. 26, an exploded, perspective side view of third phase shifting element **2400** is shown in accordance with an illustrative embodiment. With reference to FIG. 27, a bottom view of third phase shifting element **2400** is shown in accordance with an illustrative embodiment. With reference to FIG. 28A, a transparent perspective side view of third phase shifting element **2400** is shown with dielectric material removed and with electric field and current flow directions shown based on a first switch position in accordance with an illustrative embodiment. With reference to FIG. 28B, a second transparent perspective side view of third phase shifting element **2400** is shown with the dielectric material removed and with the electric field and current flow directions shown based on a second switch position in accordance with an illustrative embodiment. The separation between layers illustrated in FIGS. 26, 28A, and 28B are exaggerated to more clearly show the arrangement of the components of third phase shifting element **2400**.

Third phase shifting element **2400** may include a first dielectric layer **2402**, a conducting layer **2404**, a second dielectric layer **2406**, and a conducting pattern layer **2407**. Third phase shifting element **2400** provides a polarization rotating surface that can be used as a spatial phase shifter of a single-layer, wideband reflective array antenna. Third phase shifting element **2400** rotates a polarization of a reflected wave by 90° compared to that of an incident wave. Third phase shifting element **2400** can be switched between a first configuration and a second configuration that is a geometric mirror image of the first configuration. The two configurations provide reflected fields having a phase difference of 180° between them. Because phase shifting using third phase shifting element **2400** is achieved through geometric means, third phase shifting element **2400** can provide either 0° or 180° phase shift, acting as one-bit phase shifters, over extremely broad bandwidths.

First dielectric layer **2402** of third phase shifting element **2400** is similar to first dielectric layer **102** of phase shifting element **100**. Second dielectric layer **2406** of third phase shifting element **2400** is similar to second dielectric layer **106** of phase shifting element **100**. Conducting layer **2404** of third phase shifting element **2400** is similar to conducting layer **104** of phase shifting element **100**.

Conducting layer **2404** is mounted between first dielectric layer **2402** and second dielectric layer **2406** such that a top surface **2610** of first dielectric layer **2402** is mounted to a bottom surface of conducting layer **2404**, and second dielectric layer **2406** is mounted to a top surface **2612** of conducting layer **2404**. Each of first dielectric layer **2402**, conducting layer **2404**, and second dielectric layer **2406** has a generally square top and bottom surface shape in an x-y plane and a thickness in a vertical direction denoted by a z-axis, where an x-axis is perpendicular to a y-axis, and both the x-axis and the y-axis are perpendicular to the z-axis to form a right-handed coordinate reference frame denoted x-y-z frame **2422**. First dielectric layer **2402**, conducting

layer **2404**, and second dielectric layer **2406** have a length **2420** parallel to the x-axis, and a width **2421** parallel to the y-axis. In the illustrative embodiment, length **2420** is equal to width **2421**.

Second dielectric layer **2406** has a back wall **2408**, a right-side wall **2410**, a front wall **2412**, a left-side wall **2414**, a top surface **2415**, and a bottom surface (not shown). The bottom surface of second dielectric layer **2406** is mounted to top surface **2612** of conducting layer **2404**.

The top and bottom surfaces of each of first dielectric layer **2402**, conducting layer **2404**, and second dielectric layer **2406** are generally flat. First dielectric layer **2402** has a first thickness **2416** parallel to the z-axis. Conducting layer **2404** has a second thickness **2417** parallel to the z-axis. Second dielectric layer **106** has a third thickness **2418** parallel to the z-axis.

Conducting pattern layer **2407** is formed on top surface **2415** of second dielectric layer **2406** opposite conducting layer **2404**. Conducting pattern layer **2407** includes a first T-shaped conductor **2424a**, a second T-shaped conductor **2424b**, and a third T-shaped conductor **2424c**. First T-shaped conductor **2424a**, second T-shaped conductor **2424b**, and third T-shaped conductor **2424c** form a mirror image relative to a y-z center plane through a center **2434** of top surface **2415** of second dielectric layer **2406**. The y-z center plane is parallel to the y-z plane defined by x-y-z frame **2422**.

First T-shaped conductor **2424a** is positioned in an upper center of top surface **2415** of second dielectric layer **2406**. First T-shaped conductor **2424a** includes a first switch connector arm **2426a** and a top T-arm **2428a**. First switch connector arm **2426a** and top T-arm **2428a** are perpendicular to each other. First switch connector arm **2426a** and top T-arm **2428a** are used to describe a shape of first T-shaped conductor **2424a** and typically are not distinct elements, but form a single conductive structure. First switch connector arm **2426a** connects first T-shaped conductor **2424a** to a first via **2602a**. Top T-arm **2428a** is centered between right-side wall **2410** and left-side wall **2414** and extends parallel to the x-axis. Top T-arm **2428a** is a first distance **2500** from top wall **2408**. First switch connector arm **2426a** has an arm length **2502** and an arm width **2506**. Top T-arm **2428a** has an arm length **2508** and an arm width **2504**.

First via **2602a** forms an electrical connection between a first throw arm **2606** of switch **2604** through first dielectric layer **2402**, conducting layer **2404**, and second dielectric layer **2406** to form an electronic circuit. First via **2602a** optionally may also form an electrical connection between second throw arm **2608** of switch **2604** through first dielectric layer **2402**, conducting layer **2404**, and second dielectric layer **2406** to form a second electronic circuit. First via **2602a** is formed of a conductive material. A first dielectric patch **2600a** is formed through conducting layer **2404** of a dielectric material. First via **2602a** extends generally parallel to the z-axis through first dielectric patch **2600a**.

Second T-shaped conductor **2424b** is positioned in a right center of top surface **2415** of second dielectric layer **2406**. Second T-shaped conductor **2424b** includes a second switch connector arm **2426b** and a right T-arm **2428b**. Second switch connector arm **2426b** and right T-arm **2428b** are perpendicular to each other. Second switch connector arm **2426b** and right T-arm **2428b** are used to describe a shape of second T-shaped conductor **2424b** and typically are not distinct elements, but form a single conductive structure. Second switch connector arm **2426b** connects second T-shaped conductor **2424b** to a second via **2602b**. Right T-arm **2428b** is centered between top wall **2408** and bottom wall **2412** and extends parallel to the y-axis. Right T-arm

2428b is a first distance **2510** from right-side wall **2410**. Second switch connector arm **2426b** has an arm length **2512** and an arm width **2516**. Right T-arm **2428b** has an arm length **2518** and an arm width **2514**.

Second via **2602b** forms an electrical connection between first throw arm **2606** of switch **2604** through first dielectric layer **2402**, conducting layer **2404**, and second dielectric layer **2406** to form an electronic circuit. Second via **2602b** is formed of a conductive material. A second dielectric patch **2600b** is formed through conducting layer **2404** of a dielectric material. Second via **2602b** extends generally parallel to the z-axis through second dielectric patch **2600b**.

Third T-shaped conductor **2424c** is positioned in a left center of top surface **2415** of second dielectric layer **2406**. Third T-shaped conductor **2424c** includes a third switch connector arm **2426c** and a left T-arm **2428c**. Third switch connector arm **2426c** and left T-arm **2428c** are perpendicular to each other. Third switch connector arm **2426c** and left T-arm **2428c** are used to describe a shape of third T-shaped conductor **2424c** and typically are not distinct elements, but form a single conductive structure. Third switch connector arm **2426c** connects third T-shaped conductor **2424c** to a third via **2602c**. Left T-arm **2428c** is centered between top wall **2408** and bottom wall **2412** and extends parallel to the y-axis. Left T-arm **2428c** is a first distance **2510** from left-side wall **2414**. Third switch connector arm **2426c** has arm length **2512** and arm width **2516**. Left T-arm **2428c** has arm length **2518** and arm width **2514**.

Third via **2602c** forms an electrical connection between second throw arm **2608** of switch **2604** through first dielectric layer **2402**, conducting layer **2404**, and second dielectric layer **2406** to form an electronic circuit. Third via **2602c** is formed of a conductive material. A third dielectric patch **2600c** is formed through conducting layer **2404** of a dielectric material. Third via **2602c** extends generally parallel to the z-axis through third dielectric patch **2600c**.

Switch **2604** is a single pole, double throw (SPDT) switch. In a first position, first throw arm **2606** of switch **2604** is closed to electrically connect first via **2602a** and second via **2602b**. In a second position, second throw arm **2608** of switch **2604** is closed to electrically connect first via **2602a** and third via **2602c**. Switch **2604** is mounted to bottom surface **2700** of first dielectric layer **2402**. When switch **2604** is in the first position, third phase shifting element **2400** may be designated as in a bit zero configuration. When switch **2604** is in the second position, third phase shifting element **2400** may be designated as in a bit one configuration. Switch **2604** may be a mechanical switch, a MEMS switch, a commercially available SPDT switch, a plurality of PIN diodes, etc.

In the first position, first throw arm **2606** of switch **2604** is closed to electrically connect first via **2602a** and second via **2602b** thereby electrically connecting first T-shaped conductor **2424a** to second T-shaped conductor **2424b**. Referring to FIG. 28A, for an incident wave with an incident electric field E_i **2800** in the $-x$ direction parallel to the x-axis, a periodic structure consisting of third phase shifting elements **2400** in the bit zero configuration rotates the polarization of the reflected wave by 90° resulting in a reflected wave with a reflected electric field E_r **2808** in the $+y$ direction parallel to the y-axis.

In the second position, second throw arm **2608** of switch **2604** is closed to electrically connect first via **2602a** and third via **2602c** thereby electrically connecting first T-shaped conductor **2424a** to third T-shaped conductor **2424c**. Referring to FIG. 28B, for the incident wave with incident electric field E_i **2800** in the $-x$ direction parallel to the x-axis, a

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periodic structure consisting of third phase shifting elements **2400** in the bit one configuration rotates the polarization of the reflected wave by -90° resulting in a reflected wave with a reflected electric field E_r , **2816** in the $-y$ direction parallel to the y -axis. As a result, depending on whether third phase shifting elements **2400** is in the bit zero configuration or in the bit one configuration based on the position of switch **2604**, third phase shifting elements **2400** rotates the polarization of the reflected electric field by $+90^\circ$ or by -90° compared to that of the incident electric field.

Referring to FIG. **28A**, when illuminated with the incident waves polarized along the $-x$ direction, a first electric current **2804** and a second electric current **2805** are induced on second switch connector arm **2426b** and on third switch connector arm **2426c**. First T-shaped conductor **2424a**, first via **2602a**, first throw arm **2606** of switch **2604**, second via **2602b**, and second T-shaped conductor **2424b**, form an extended electrical pathway that has an electrical length of approximately a wavelength. This results in a current minimum around the switch as well as the currents flowing in the same direction on first via **2602a** and on second via **2602b**. This dictates the direction of a third electric current **2806** on first switch connector arm **2426a**. As a result, third phase shifting element **2400** produces a first effective current **2807a** and a second effective current **2807b** that make an angle of 225° relative to the x -axis. Third phase shifting element **2400** acts as a perfect electric conductor for reflecting a first component of incident electric field E_i , **2800** parallel to the direction of first effective current **2807a** and of second effective current **2807b**, and as a perfect magnetic conductor for reflecting a second component of incident electric field E_i , **2800** orthogonal to the direction of first effective current **2807a** and of second effective current **2807b**. This leads to reflected electric field E_r , **2808** polarized in the $+y$ direction parallel to the y -axis.

Referring to FIG. **28B**, when illuminated with the incident waves polarized along the $-x$ direction, a first electric current **2812** and a second electric current **2813** are induced on second switch connector arm **2426b** and on third switch connector arm **2426c**. First T-shaped conductor **2424a**, first via **2602a**, first throw arm **2606** of switch **2604**, second via **2602b**, and second T-shaped conductor **2424b**, form an extended electrical pathway that has an electrical length of approximately a wavelength. This results in a current minimum around the switch as well as the currents flowing in the same direction on first via **2602a** and on third via **2602c**. This dictates the direction of a third electric current **2814** on first switch connector arm **2426a**. As a result, third phase shifting element **2400** produces a first effective current **2815a** and a second effective current **2815b** that make an angle of 135° relative to the x -axis. Third phase shifting element **2400** acts as a perfect electric conductor for reflecting the first component of incident electric field E_i , **2800** parallel to the direction of first effective current **2815a** and of second effective current **2815b**, and as a perfect magnetic conductor for reflecting the second component of incident electric field E_i , **2800** orthogonal to the direction of first effective current **2815a** and of second effective current **2815b**. This leads to reflected electric field E_r , **2816** polarized in the $-y$ direction parallel to the y -axis.

Dimensions for third phase shifting element **2400** can be determined based on the following:

$$0 < P \leq \frac{\lambda_0}{2}$$

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-continued

$$\frac{\lambda_{eff}}{10} \leq l_1 \leq \frac{\lambda_{eff}}{4}; l_1 < \frac{P}{2}; \lambda_{eff} \approx \frac{\lambda_0}{\sqrt{\frac{1+\epsilon_{r,1}}{2}}}$$

$$\frac{\lambda_{eff}}{10} \leq l_2 \leq \frac{\lambda_{eff}}{4}$$

$$\frac{\lambda_{eff}}{10} \leq l_3 \leq \frac{\lambda_{eff}}{4}$$

$$\frac{\lambda_{eff}}{10} \leq l_4 \leq \frac{\lambda_{eff}}{4}$$

$$\frac{\lambda_0}{10} \leq h_1 \times \sqrt{\epsilon_{r,1}} + \dots + h_{n-1} \times \sqrt{\epsilon_{r,n-1}} \leq \frac{\lambda_0}{3}$$

$$0 \leq h_m \times \sqrt{\epsilon_{r,m}} < \lambda_0$$

$$0 < w_1 \leq \frac{\lambda_0}{10}, 0 < w_2 \leq \frac{\lambda_0}{10}$$

$$0 < w_3 \leq \frac{\lambda_0}{10}, 0 < w_4 \leq \frac{\lambda_0}{10}$$

$$0 < s \leq \frac{\lambda_0}{10}$$

where λ_0 is a wavelength of operation and is defined as $\lambda_0 = c/f_0$, where c is the speed of light and f_0 is a carrier frequency, where P is length **2420** and width **2421**, l_1 is arm length **2502**, w_1 is arm width **2506**, l_2 is arm length **2508**, w_2 is arm width **2504**, s is first distance **2500** and first distance **2510**, l_3 is arm length **2512**, w_3 is arm width **2516**, l_4 is arm length **2518**, w_4 is arm width **2514**, $\epsilon_{r,1}$ is a relative permittivity of a top layer of second dielectric layer **2406**, h_1 is third thickness **2418** of the top layer of second dielectric layer **2406**, $\epsilon_{r,n-1}$ is a relative permittivity of a next layer of second dielectric layer **2406** when second dielectric layer **2406** is formed of a plurality of dielectric layers n , h_{n-1} is a thickness of the next layer of second dielectric layer **2406** when second dielectric layer **2406** is formed of a plurality of dielectric layers n , $\epsilon_{r,m}$ is a relative permittivity of first dielectric layer **2402**, h_m is first thickness **2416** of first dielectric layer **2402**. When second dielectric layer **2406** is formed of the plurality of dielectric layers n , third thickness **2418** is a total thickness of second dielectric layer **2406**.

Referring to FIG. **29**, a perspective side view of a fourth phase shifting element **2900** is shown in accordance with an illustrative embodiment. Fourth phase shifting element **2900** includes first dielectric layer **2402**, conducting layer **2404**, a fourth dielectric layer **2406a**, and conducting pattern layer **2407**. Fourth dielectric layer **2406a** is similar to second dielectric layer **2406** except that it is formed of two dielectric layers, a top dielectric layer **2902** and a sandwiched dielectric layer **2904**. Conducting pattern layer **2407** is formed on top surface **2415** of top dielectric layer **2902**. Top dielectric layer **2902** has a fourth thickness **2906**. Sandwiched dielectric layer **2904** is between top dielectric layer **2902** and conducting layer **2404** and has a fifth thickness **2908**. In the illustrative embodiment of FIG. **29**, sandwiched dielectric layer **2904** is formed of RO3006 material. Top dielectric layer **2902** and first dielectric layer **2902** are formed of RO4003C material with a dielectric constant of 3.4 and a loss tangent of 0.0027.

Fourth phase shifting element **2900** was constructed in two embodiments to correspond with either the first position or the second position of switch **2604**. Illustrative dimensions for second phase shifting element **600** are $P=8$ mm for length **2420** and width **2421**, $l_1=3.6$ mm for arm length **2502**, $w_1=0.3$ mm for arm width **2506**, $l_2=2$ mm for arm length **2508**, $w_2=0.3$ mm for arm width **2504**, $s=0.2$ mm for

first distance **2500** and first distance **2510**, $l_3=1.9$ mm for arm length **2512**, $w_3=0.3$ mm for arm width **2516**, $l_4=2$ mm for arm length **2518**, $w_4=0.3$ mm for arm width **2514**, $\epsilon_{r,1}$ is a relative permittivity of RO4003C material, $h_1=0.4$ mm for fourth thickness **2906**, $\epsilon_{r,2}$ is a relative permittivity of RO3006 material, $h_2=2.6$ mm for fifth thickness **2908** such that third thickness **2418** is 3 mm, $\epsilon_{r,m}$ is a relative permittivity of RO4003C material, and $h_m=0.4$ mm for first thickness **2416** of first dielectric layer **2402**.

Referring to FIG. 30, an X-Y reflection coefficient curve **3000** and a Y-Y reflection coefficient curve **3002** show an X-Y reflection coefficient and a Y-Y reflection coefficient, respectively, as a function of frequency that result when using fourth phase shifting element **2900** designed using the illustrative dimensions above. Incident electric field plane **1200** was polarized parallel to the y-axis.

Referring to FIG. 31, a phase difference curve **3100** shows a phase difference as a function of frequency between the two embodiments of fourth phase shifting element **2900** in the first switch position and in the second switch position in accordance with an illustrative embodiment. The phase difference is 180° within the intended operating frequency range (e.g. 8.3-11.2 GHz) of fourth phase shifting element **2900**. The blip in phase difference curve **3100** that occurred at ~ 12.3 GHz is likely due to a transition between R_{yy} -dominant reflection to R_{xx} -dominant reflection around this frequency as shown in FIG. 30. This frequency is outside of the intended operating frequency range of second phase shifting element **600** (e.g. 8.3-11.2 GHz) so it is not a concern.

The combination of feed antenna **702** and the plurality of phase shifting elements form a high-gain antenna. A direction of maximum radiation of the high-gain antenna is determined by the phase shift gradient of the electric field distribution over the aperture of the plurality of phase shifting elements. Because the phase shift gradient is dynamically changeable by changing the position of switch **304** or of switch **2604** for each phase shifting element across the aperture, a direction of maximum radiation of the antenna also changes. Such a dynamically reconfigurable system constitutes a beam steerable phased array. Multiple steerable beams can be formed by multiple feed antennas.

The described phase shifting elements are easy to implement and make tunable (i.e., change the electric field rotation from -90° to 90° causing either a 0° or 180° relative phase shift between the reflected waves) using simple electrical switches. As a result, a phased-array implemented using the described phase shifting elements has significantly lower complexity and cost compared to alternative techniques. Moreover, the physics of beam steering and the nature of the described phase shifting elements allows for these phased arrays to handle relatively high levels of radiated power. The described phase shifting elements also provide a simple structure that achieves wideband operation. The described phase shifting elements do not use any nonlinear elements or any solid-state phase shifters or transmit/receive modules. As a result, apertures designed using the described phase shifting elements can handle significantly higher power levels in comparison with the existing technology. This feature is significant especially for millimeter-wave (MMW) communication systems. At MMW frequencies, the propagation losses are significantly higher compared to microwave frequencies. As a result, transmitters used at these frequencies must be able to radiate higher power levels to ensure that a communication link in the desired distance can be established.

The described phase shifting elements also do not require complex thermal management solutions to cool down the aperture of the antenna due to the fact that all the heat generating components are removed from the aperture. This significantly reduces the cost and complexity of thermal management of the array. This also reduces the weight of the phased-array.

As used herein, the term “mount” includes join, unite, connect, couple, associate, insert, hang, hold, affix, attach, fasten, bind, paste, secure, bolt, screw, rivet, solder, weld, glue, form over, form in, layer, mold, rest on, rest against, etch, abut, and other like terms. The phrases “mounted on”, “mounted to”, and equivalent phrases indicate any interior or exterior portion of the element referenced. These phrases also encompass direct mounting (in which the referenced elements are in direct contact) and indirect mounting (in which the referenced elements are not in direct contact, but are connected through an intermediate element). Elements referenced as mounted to each other herein may further be integrally formed together, for example, using a molding or a thermoforming process as understood by a person of skill in the art. As a result, elements described herein as being mounted to each other need not be discrete structural elements. The elements may be mounted permanently, removably, or releasably unless specified otherwise.

The word “illustrative” is used herein to mean serving as an example, instance, or illustration. Any aspect or design described herein as “illustrative” is not necessarily to be construed as preferred or advantageous over other aspects or designs. Further, for the purposes of this disclosure and unless otherwise specified, “a” or “an” means “one or more”. Still further, using “and” or “or” in the detailed description is intended to include “and/or” unless specifically indicated otherwise. The illustrative embodiments may be implemented as a method, apparatus, or article of manufacture using standard programming and/or engineering techniques to produce software, firmware, hardware, or any combination thereof to control a computer to implement the disclosed embodiments.

Any directional references used herein, such as left-side, right-side, top, bottom, back, front, up, down, above, below, etc., are for illustration only based on the orientation in the drawings selected to describe the illustrative embodiments.

The foregoing description of illustrative embodiments of the disclosed subject matter has been presented for purposes of illustration and of description. It is not intended to be exhaustive or to limit the disclosed subject matter to the precise form disclosed, and modifications and variations are possible in light of the above teachings or may be acquired from practice of the disclosed subject matter. The embodiments were chosen and described in order to explain the principles of the disclosed subject matter and as practical applications of the disclosed subject matter to enable one skilled in the art to utilize the disclosed subject matter in various embodiments and with various modifications as suited to the particular use contemplated.

What is claimed is:

1. A phase shifter comprising:

- a first dielectric layer including a top, first dielectric surface and a bottom, first dielectric surface, wherein the top, first dielectric surface is on an opposite side of the first dielectric layer relative to the bottom, first dielectric surface, wherein the first dielectric layer is formed of a dielectric material;
- a switch mounted to the bottom, first dielectric surface, the switch configured to be switchable between a first

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- conducting position defined by a first throw arm and a second conducting position defined by a second throw arm;
- a conductive layer including a top conductive surface and a bottom conductive surface, wherein the top conductive surface is on an opposite side of the conductive layer relative to the bottom conductive surface, wherein the bottom conductive surface is mounted to the top, first dielectric surface, wherein the conductive layer is formed of a first conductive material;
- a second dielectric layer including a top, second dielectric surface and a bottom, second dielectric surface, wherein the top, second dielectric surface is on an opposite side of the second dielectric layer relative to the bottom, second dielectric surface, wherein the bottom, second dielectric surface is mounted to the top conductive surface, wherein the second dielectric layer is formed of a second dielectric material;
- a plurality of vias, wherein each via of the plurality of vias is formed of a second conductive material that extends through the first dielectric layer, through a third dielectric material formed in and through the conductive layer, and through the second dielectric layer, wherein each via of the plurality of vias is connected to the first throw arm or to the second throw arm of the switch; and
- a conducting pattern layer comprising a plurality of conductors, wherein the plurality of conductors is mounted to the top, second dielectric surface, wherein the conducting pattern layer is formed of a third conductive material, wherein each conductor of the plurality of conductors is mounted to a distinct via of the plurality of vias;
- wherein the first conductive material is configured to reflect an electromagnetic wave incident on the conducting pattern layer and on the second dielectric layer, wherein, when the incident electromagnetic wave is reflected, an electric polarization of the reflected electromagnetic wave is rotated by 90 degrees compared to an electric polarization of the incident electromagnetic wave when the switch is positioned in the first conducting position and the electric polarization of the reflected electromagnetic wave is rotated by -90 degrees compared to the electric polarization of the incident electromagnetic wave when the switch is positioned in the second conducting position.
2. The phase shifter of claim 1, wherein at least one of the first conductive material, the second conductive material, and the third conductive material is a different conductive material.
3. The phase shifter of claim 1, wherein at least one of the first dielectric material, the second dielectric material, and the third dielectric material is a different dielectric material.
4. The phase shifter of claim 1, wherein the first dielectric layer is formed of a plurality of layers of different dielectric materials.
5. The phase shifter of claim 1, wherein the second dielectric layer is formed of a plurality of layers of different dielectric materials.
6. The phase shifter of claim 1, wherein the plurality of conductors form a mirror image relative to a plane perpendicular to the top, second dielectric surface and through a center of the top, second dielectric surface.
7. The phase shifter of claim 1, wherein the dielectric material is air.
8. The phase shifter of claim 1, wherein each conductor of the plurality of conductors has a "T" shape.

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9. The phase shifter of claim 1, wherein each conductor of the plurality of conductors has an open arrow shape.
10. The phase shifter of claim 9, wherein a tip of each open arrow shape is pointed in a direction that is 90 degrees from each adjacent tip.
11. The phase shifter of claim 1, wherein a number of the plurality of conductors is three.
12. The phase shifter of claim 1, wherein a number of the plurality of conductors is four.
13. The phase shifter of claim 1, wherein the first throw arm connects a first via of the plurality of vias to a second via of the plurality of vias, wherein a first conductor of the plurality of conductors is connected to the first via, wherein a second conductor of the plurality of conductors is connected to the second via.
14. The phase shifter of claim 13, wherein the second throw arm connects a third via of the plurality of vias to a fourth via of the plurality of vias, wherein a third conductor of the plurality of conductors is connected to the third via, wherein a fourth conductor of the plurality of conductors is connected to the fourth via.
15. The phase shifter of claim 14, wherein the plurality of conductors form a mirror image relative to a first plane perpendicular to the top, second dielectric surface and through a center of the top, second dielectric surface and relative to a second plane perpendicular to the top, second dielectric surface and through the center of the top, second dielectric surface.
16. The phase shifter of claim 13, wherein the second throw arm connects the first via of the plurality of vias to a third via of the plurality of vias, wherein a third conductor of the plurality of conductors is connected to the third via.
17. The phase shifter of claim 1, wherein the switch is a double pole, double throw switch.
18. The phase shifter of claim 1, wherein an electrical path length of each conductor of the plurality of conductors mounted to the distinct via of the plurality of vias is approximately a quarter of a wavelength $\lambda_0/4$, where $\lambda_0=c/f_0$, where c is a speed of light and f_0 is a carrier frequency of the incident electromagnetic wave.
19. The phase shifter of claim 1, wherein the switch is a single pole, double throw switch, and wherein an electrical path length of each conductor of the plurality of conductors mounted to the distinct via of the plurality of vias is approximately a half of a wavelength $\lambda_0/2$, where $\lambda_0=c/f_0$, where c is a speed of light and f_0 is a carrier frequency of the incident electromagnetic wave.
20. A phased array antenna comprising:
 a feed antenna configured to radiate an electromagnetic wave; and
 a plurality of phase shift elements distributed linearly in a direction, wherein each phase shift element of the plurality of phase shift elements comprises
 a first dielectric layer including a top, first dielectric surface and a bottom, first dielectric surface, wherein the top, first dielectric surface is on an opposite side of the first dielectric layer relative to the bottom, first dielectric surface, wherein the first dielectric layer is formed of a dielectric material;
 a switch mounted to the bottom, first dielectric surface, the switch configured to be switchable between a first conducting position defined by a first throw arm and a second conducting position defined by a second throw arm;
 a conductive layer including a top conductive surface and a bottom conductive surface, wherein the top conductive surface is on an opposite side of the

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conductive layer relative to the bottom conductive surface, wherein the bottom conductive surface is mounted to the top, first dielectric surface, wherein the conductive layer is formed of a first conductive material;

a second dielectric layer including a top, second dielectric surface and a bottom, second dielectric surface, wherein the top, second dielectric surface is on an opposite side of the second dielectric layer relative to the bottom, second dielectric surface, wherein the bottom, second dielectric surface is mounted to the top conductive surface, wherein the second dielectric layer is formed of a second dielectric material;

a plurality of vias, wherein each via of the plurality of vias is formed of a second conductive material that extends through the first dielectric layer, through a third dielectric material formed in and through the conductive layer, and through the second dielectric layer, wherein each via of the plurality of vias is connected to the first throw arm or to the second throw arm of the switch; and

a conducting pattern layer comprising a plurality of conductors, wherein the plurality of conductors is

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mounted to the top, second dielectric surface, wherein the conducting pattern layer is formed of a third conductive material, wherein each conductor of the plurality of conductors is mounted to a distinct via of the plurality of vias;

wherein the first conductive material is configured to reflect the radiated electromagnetic wave incident on the conducting pattern layer and on the second dielectric layer,

wherein, when the incident electromagnetic wave is reflected, an electric polarization of the reflected electromagnetic wave is rotated by 90 degrees compared to an electric polarization of the incident electromagnetic wave when the switch is positioned in the first conducting position and the electric polarization of the reflected electromagnetic wave is rotated by -90 degrees compared to the electric polarization of the incident electromagnetic wave when the switch is positioned in the second conducting position.

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